

Electron Optics in Graphene Heterostructures with Nanopatterning

Scott Dietrich¹, Shaowen Chen^{1,2}, Zheng Han^{1,7}, Mirza M. Elahi³, K. M. Masum Habib³, Lei Wang⁴, Bo Wen^{1,8}, Huan Hu⁸, Yuanda Gao⁵, Takashi Taniguchi⁶, Kenji Watanabe⁶, James Hone⁵, Avik W. Ghosh³, and Cory Dean¹

¹*Department of Physics, Columbia University, New York, NY 10027, USA.*

²*Department of Applied Physics and Applied Mathematics, Columbia University, New York, NY 10027, USA.*

³*Department of Electrical and Computer Engineering, University of Virginia, Charlottesville, VA 22904, USA.*

⁴*Department of Physics, Cornell University, Ithaca, NY 14853, USA.*

⁵*Department of Mechanical Engineering, Columbia University, New York, NY 10027, USA.*

⁶*National Institute for Materials Science, 1-1 Namiki, Tsukuba 305-0047, Japan.*

⁷*Shenyang National Laboratory for Materials Science, Institute of Metal Research, Chinese Academy of Sciences, Shenyang 110016, P. R. China.*

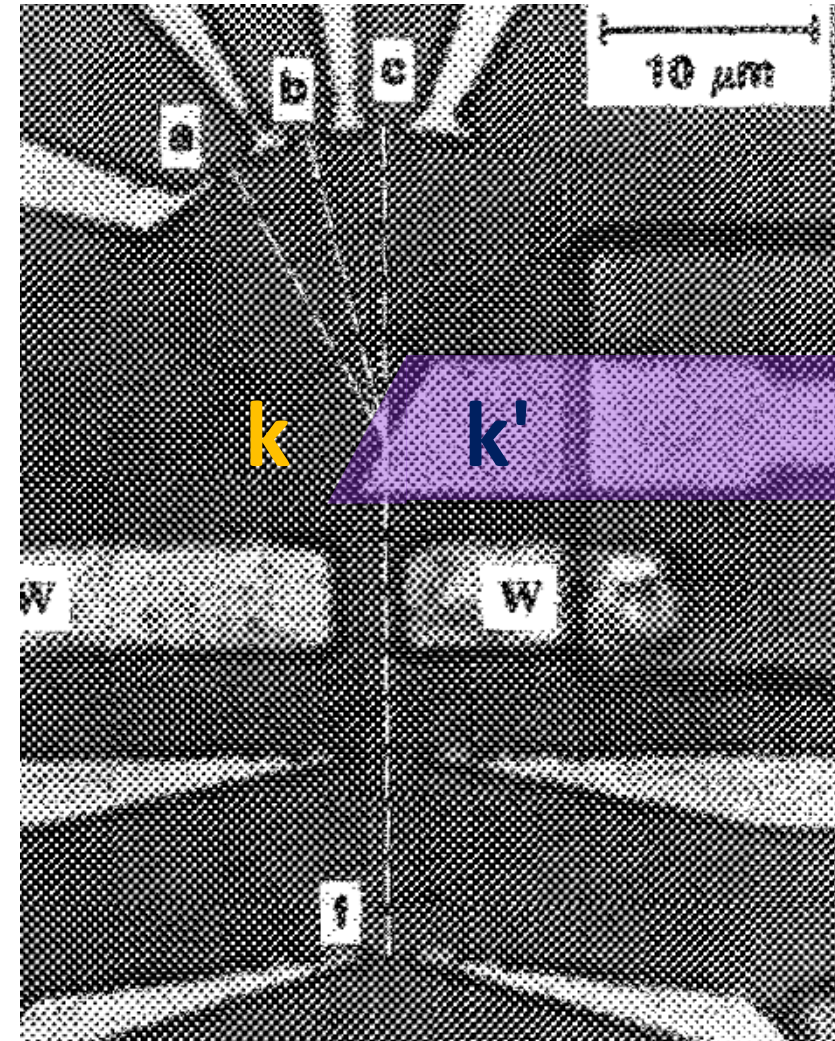
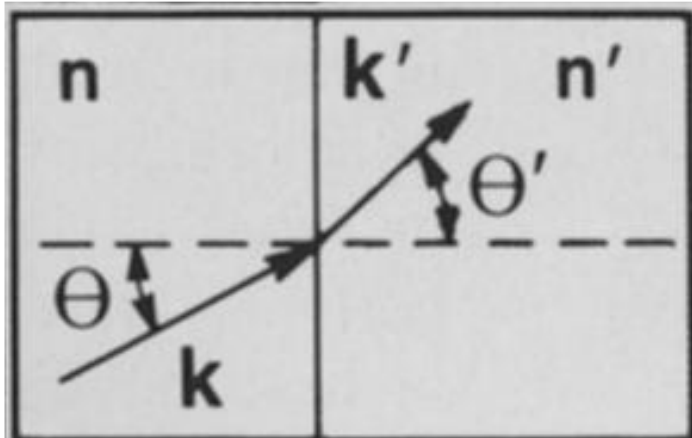
⁸*IBM Thomas J. Watson Research Center, 1101 Kitchawan Road, Yorktown Heights, NY 10598, USA. USA.*

Agenda

- Background
 - Electron optics in conventional semiconductors
 - Current state of graphene FETs and the Veselago lens
- Metrology of split-gate junctions
 - Quantifying device quality
 - Transverse magnetic focusing experiments
 - Snell's Law
 - Measuring effective junction width
- Band structure engineering through superlattice gating
 - Dielectric modulation technique
 - Device design
 - Application to a split-gate graphene FET

Ballistic electron refraction

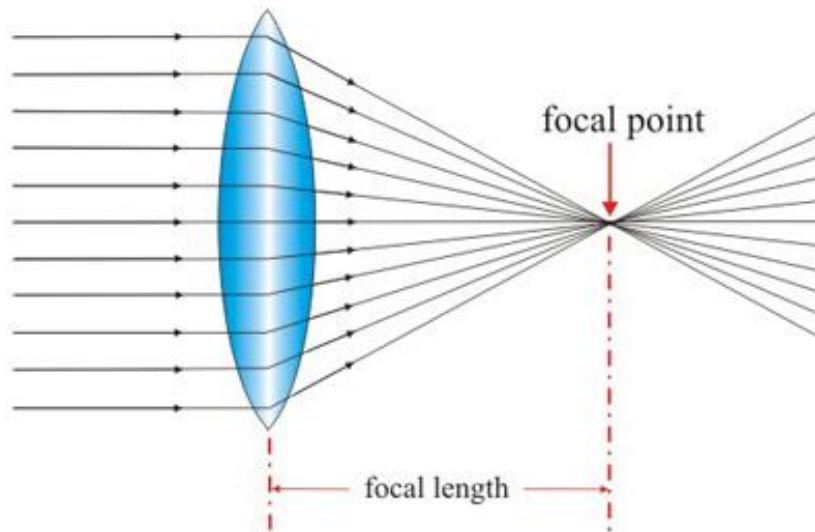
$$l_{mfp} = \tau \cdot v_F > L_{device}$$



Ballistic electron optics

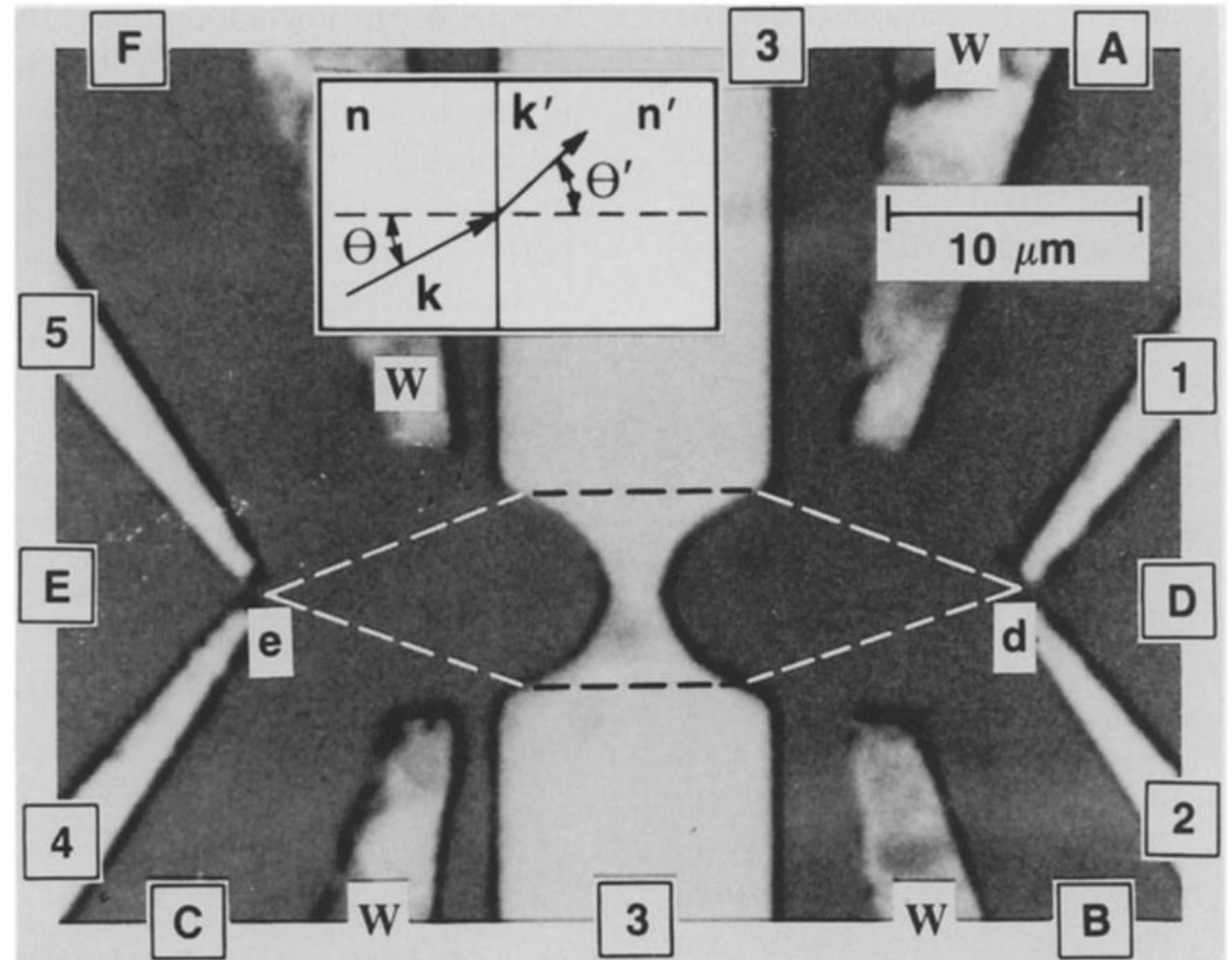
2DEG ballistic transport

- Snell's Law
- Electron optics "lens"

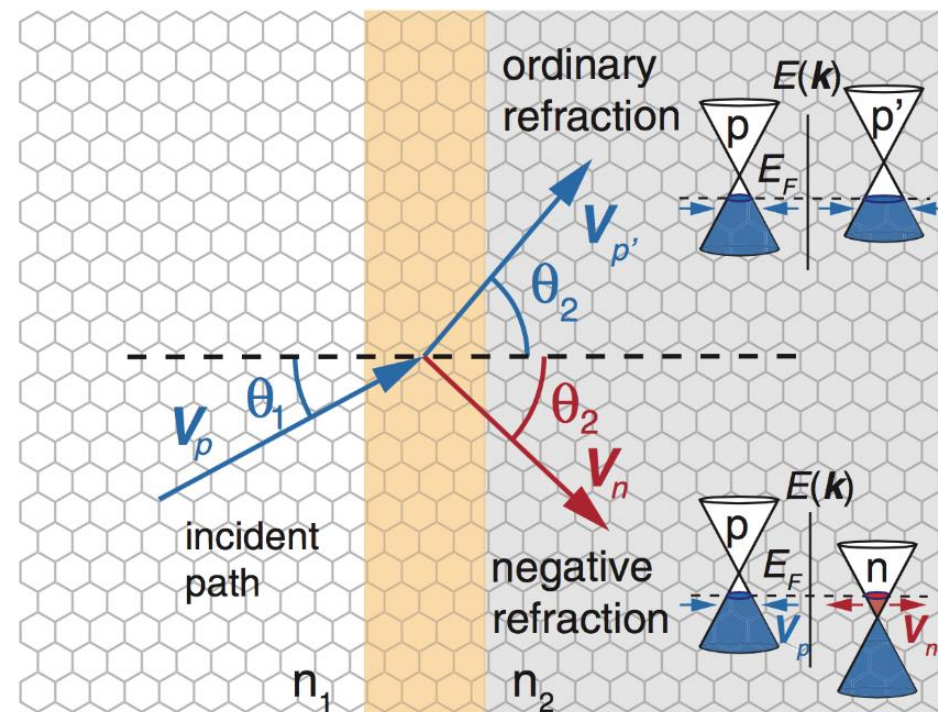
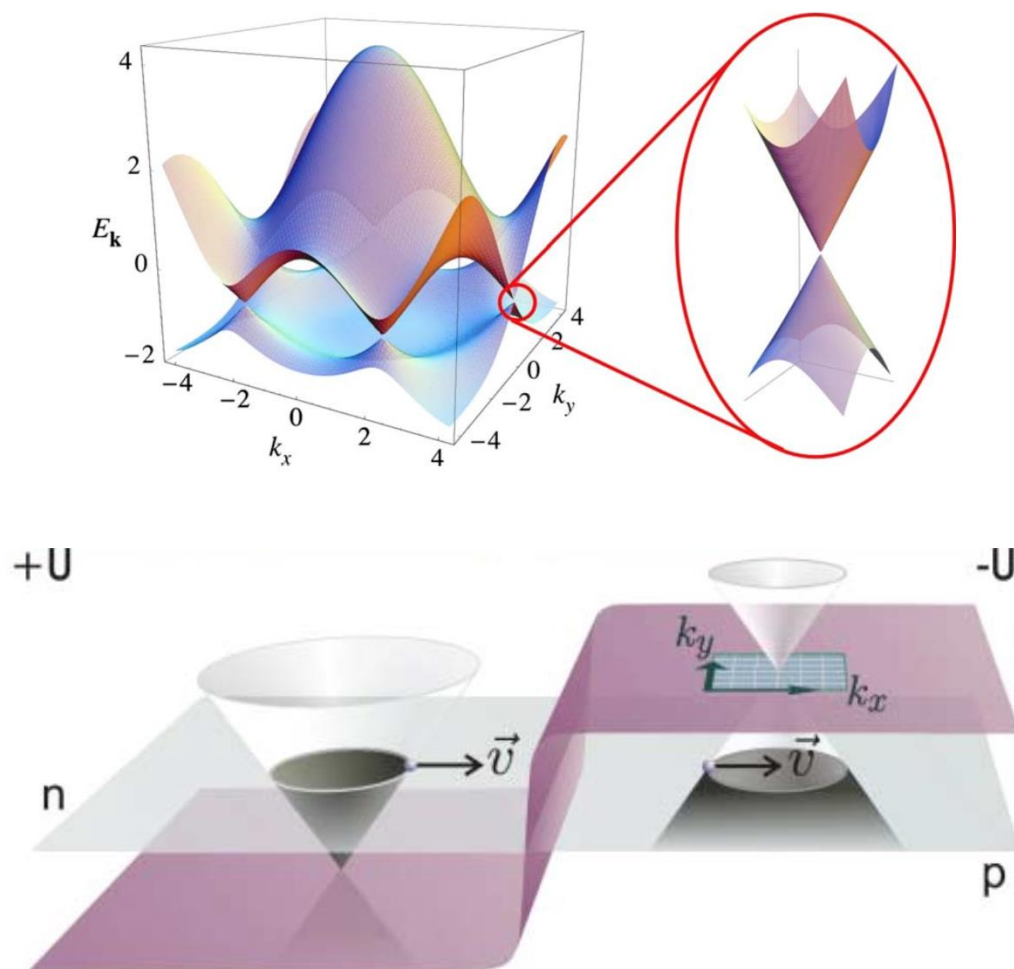


Analog of an optical convex lens

Conserve transverse momentum



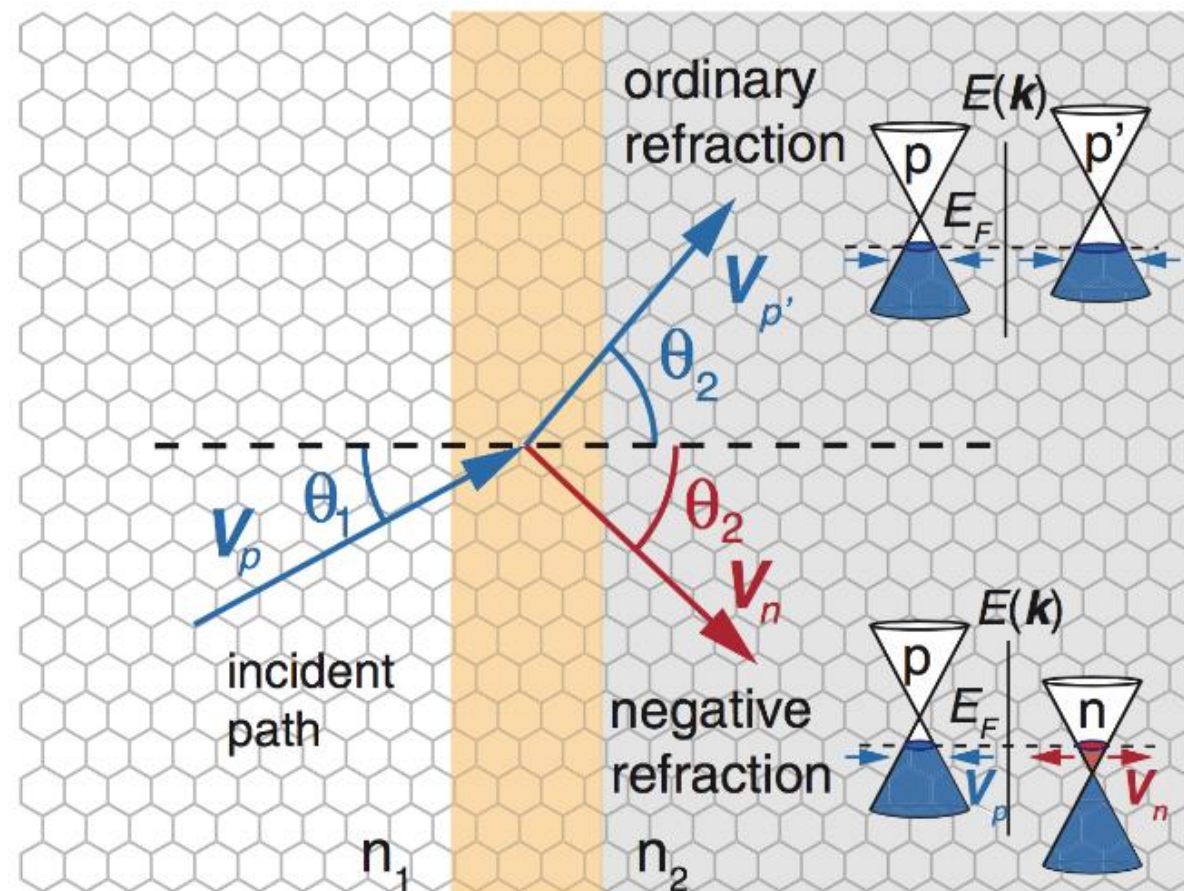
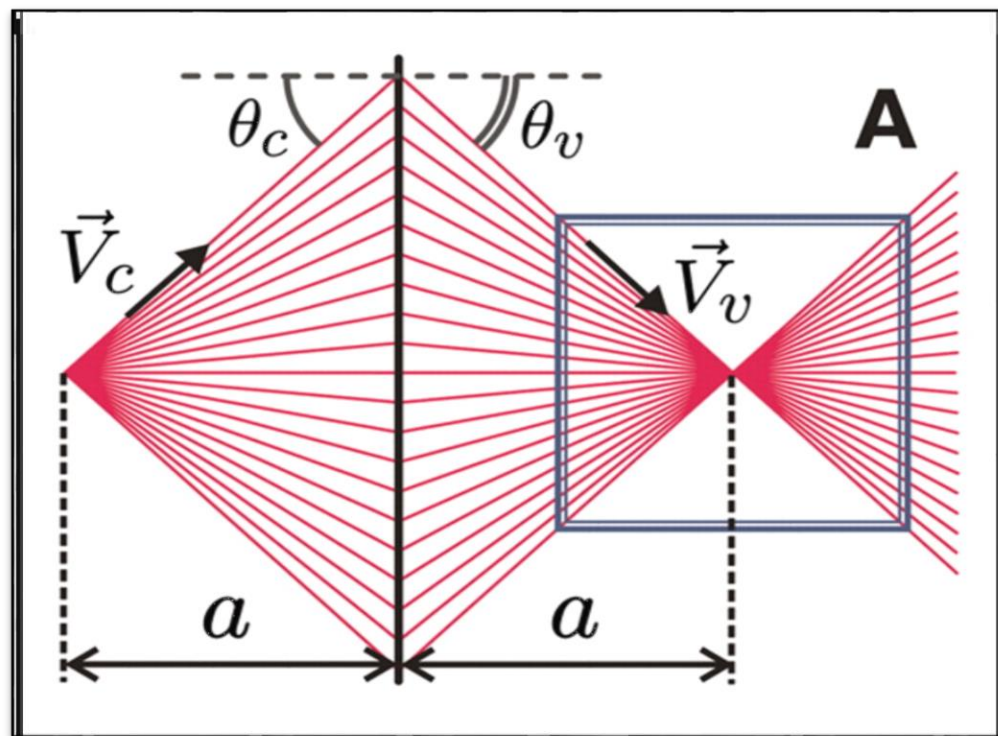
Ballistic p-n junctions in graphene



$$\frac{\sin \theta}{\sin \theta'} = -\frac{k'}{k}$$

Cheianov, et. al. *Science* **315** (2007).

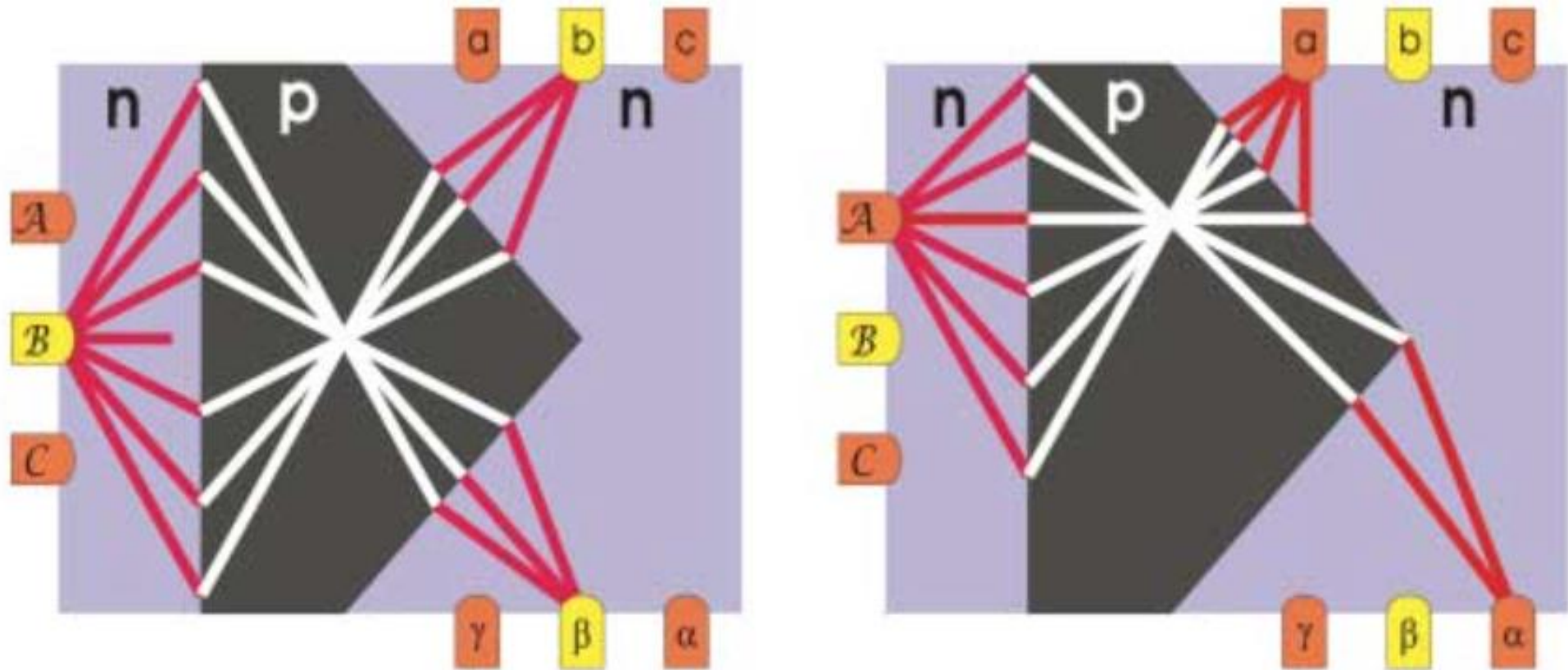
Veselago lens



Ballistic p-n junction
 Negative refraction
 Perfect lens ($p = n$)

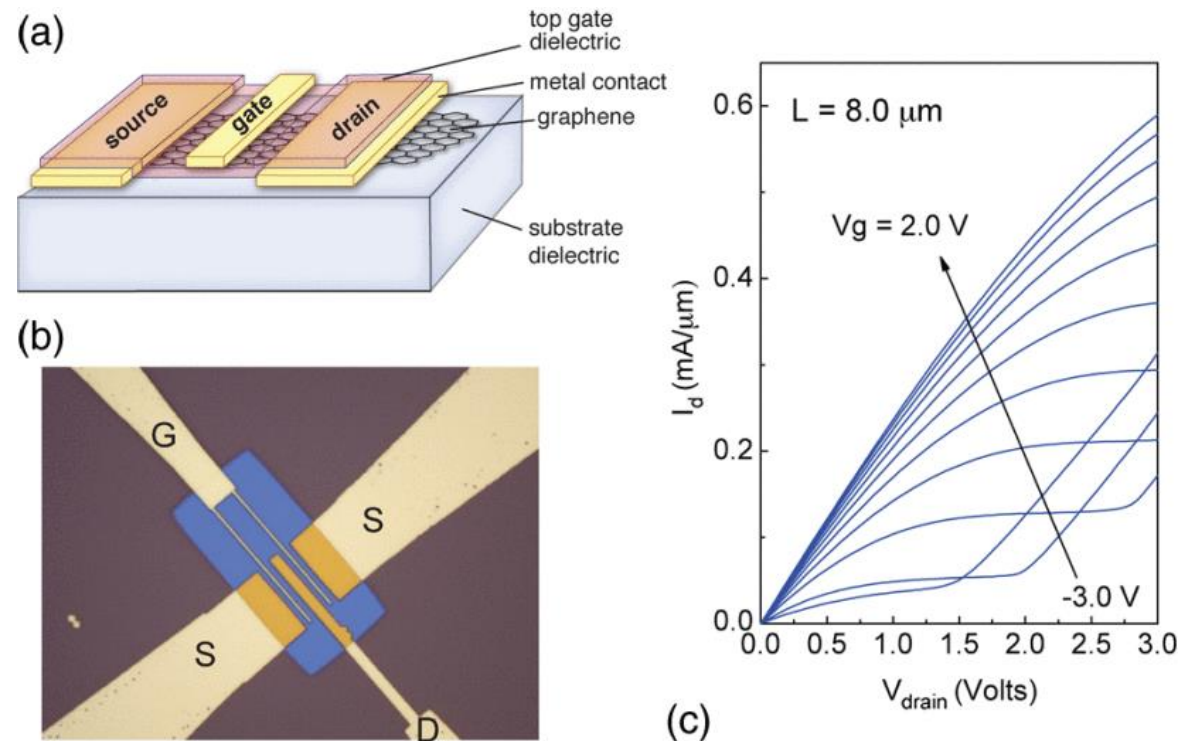
Electronic switches

Theoretical n-p-n junction beam splitter



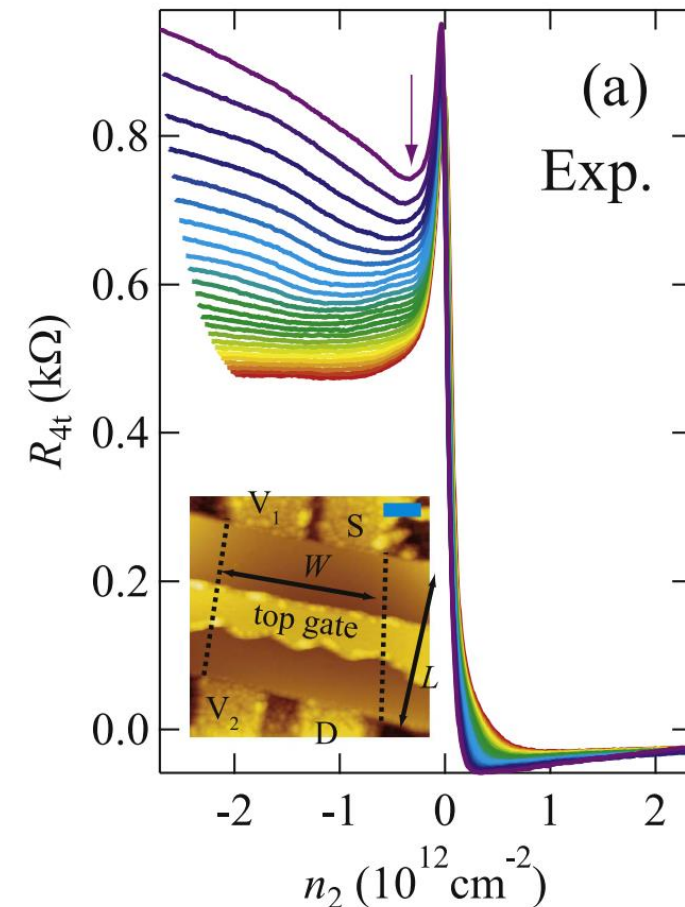
Graphene field effect transistors (gFETs)

Bilayer (non-ballistic)



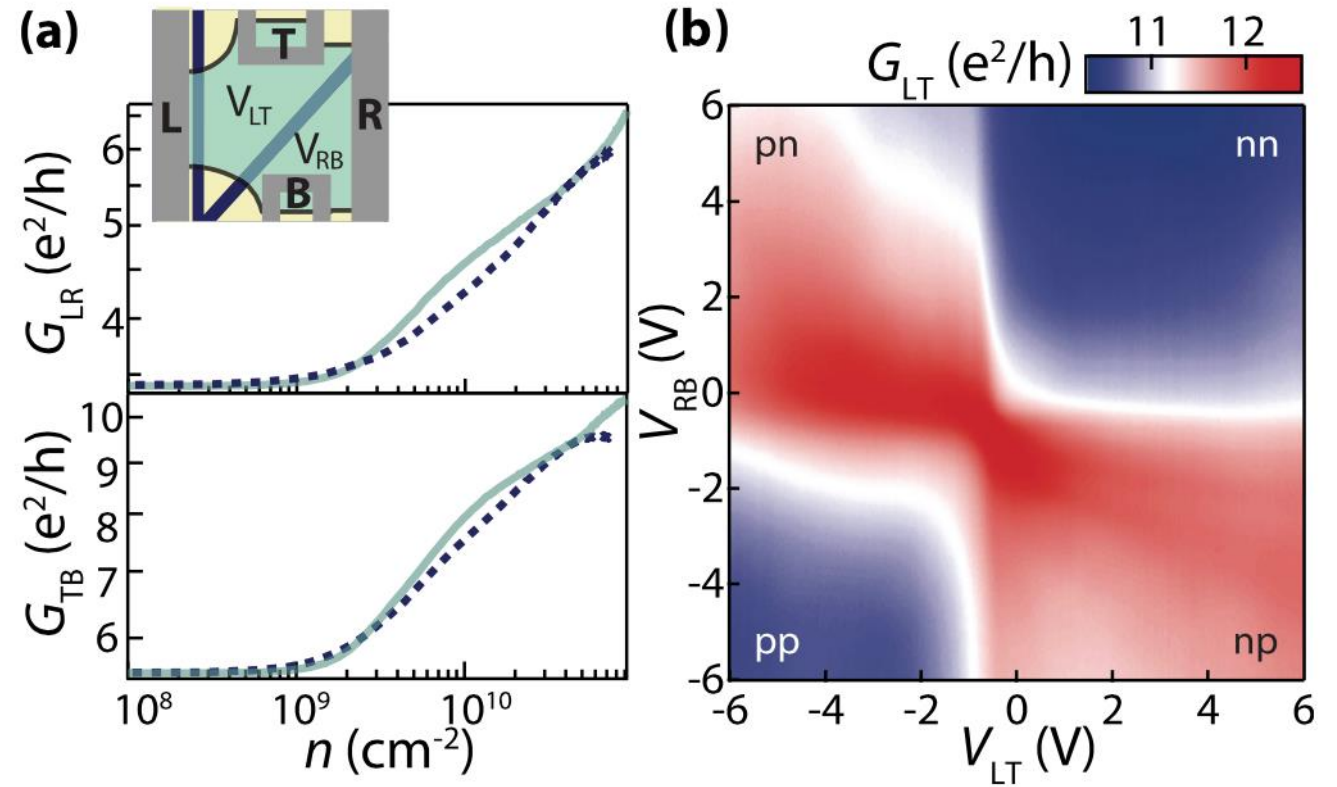
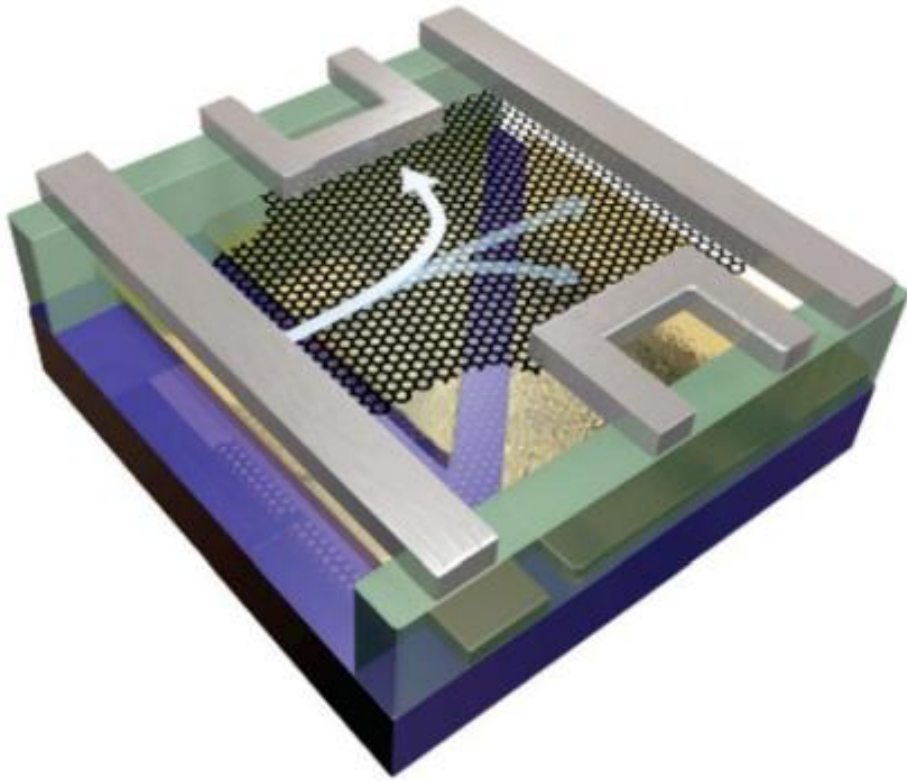
Kim et. al. [Proceedings of the IEEE](#) 101, 7 (2013)

Sawtooth gated ballistic monolayer

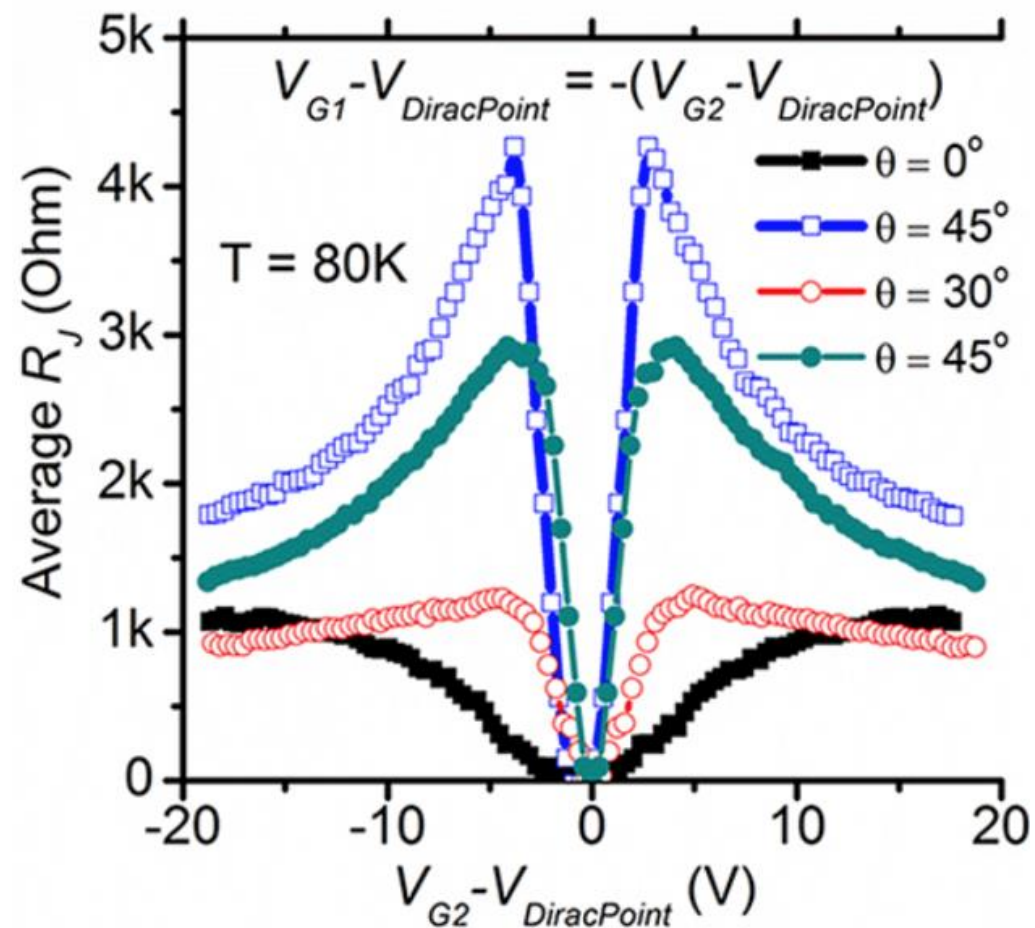
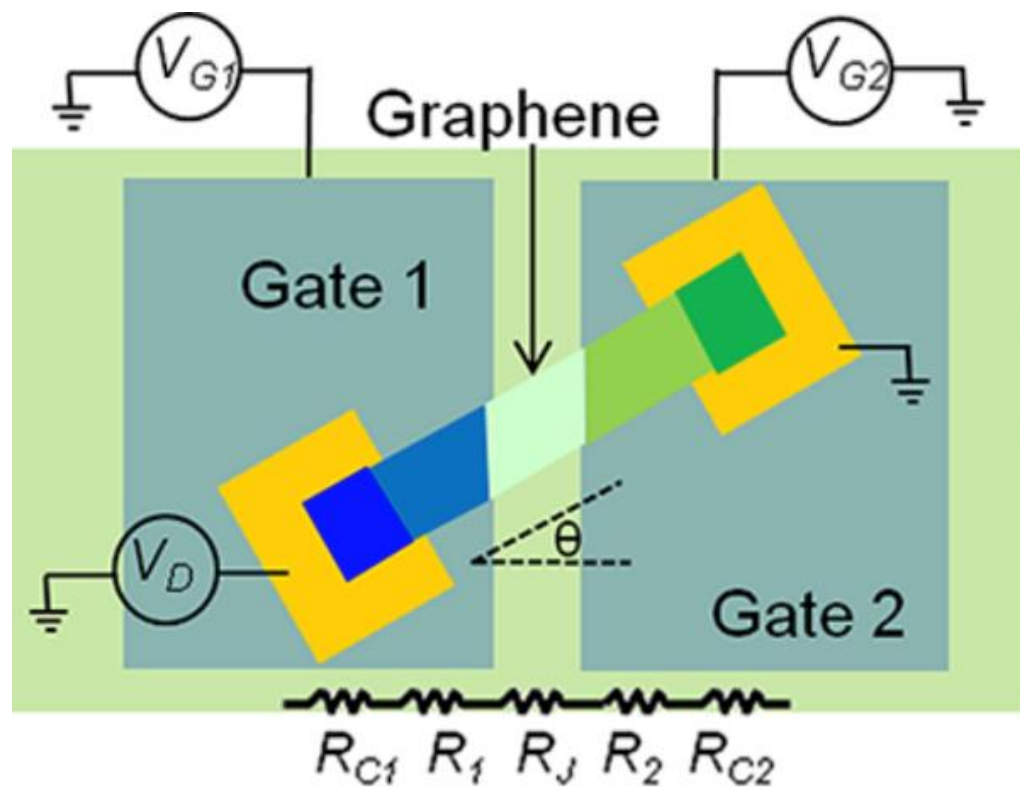


Morikawa, et al. arXiv:1702.04039 (2017)

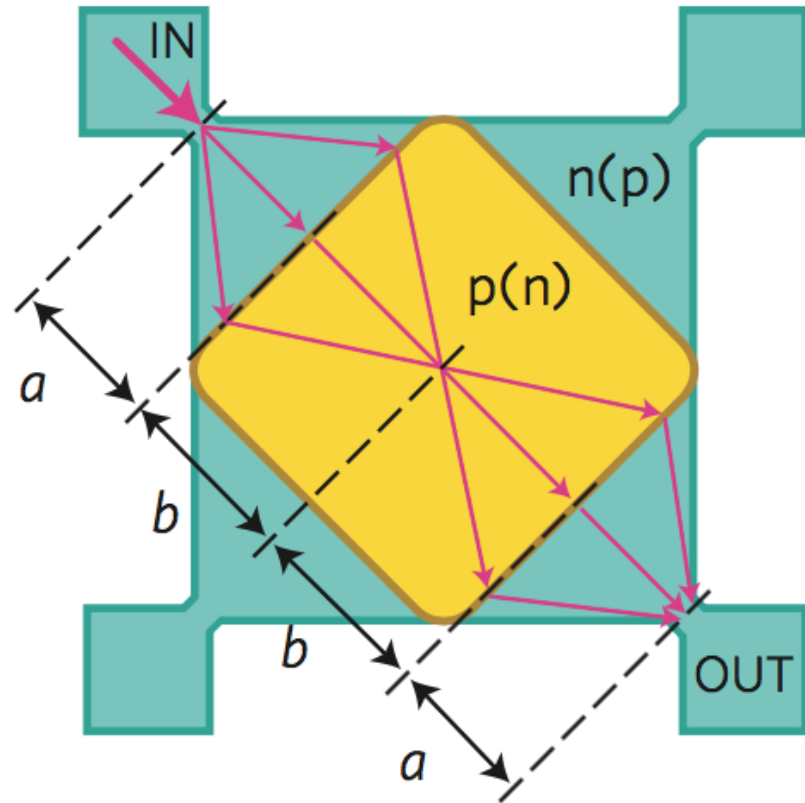
Previous work: beam splitter



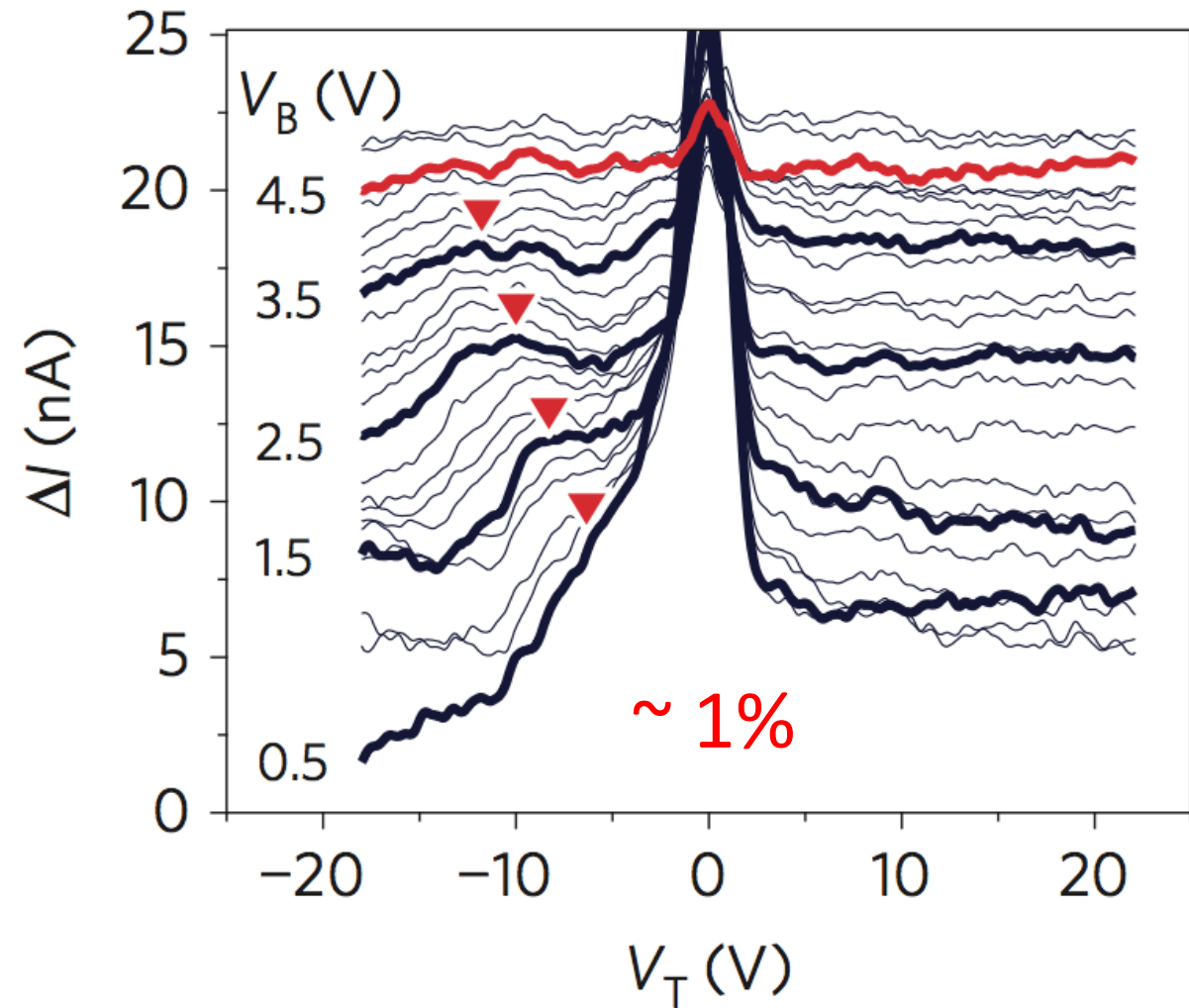
Previous work: angular-dependent transmission



PNP junctions

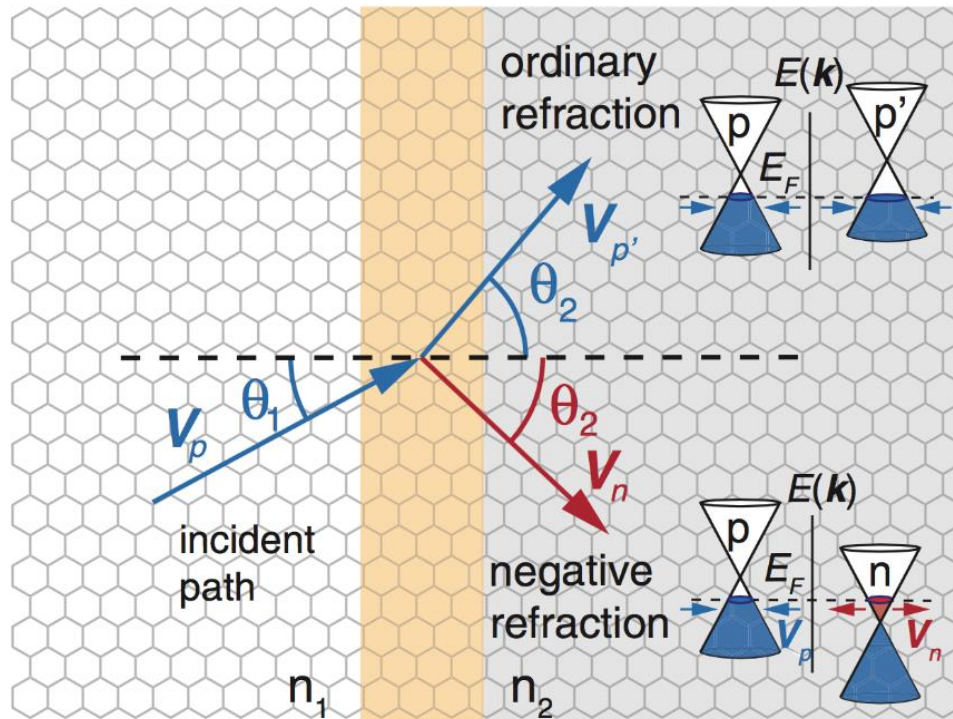


Background by normal incident electrons

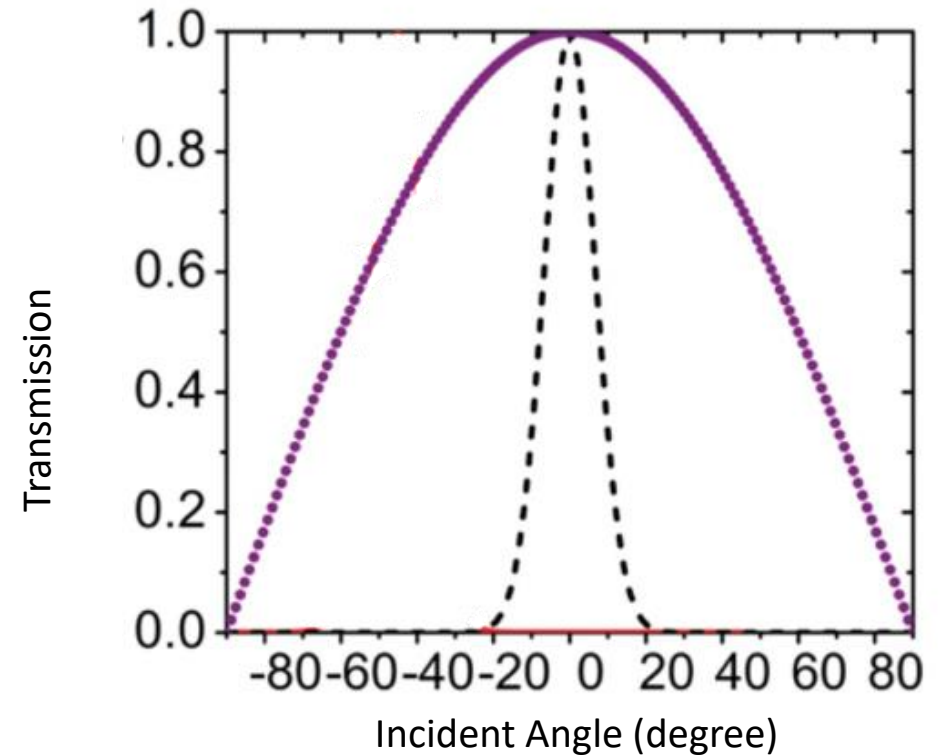


Yet to be observed

Negative refraction

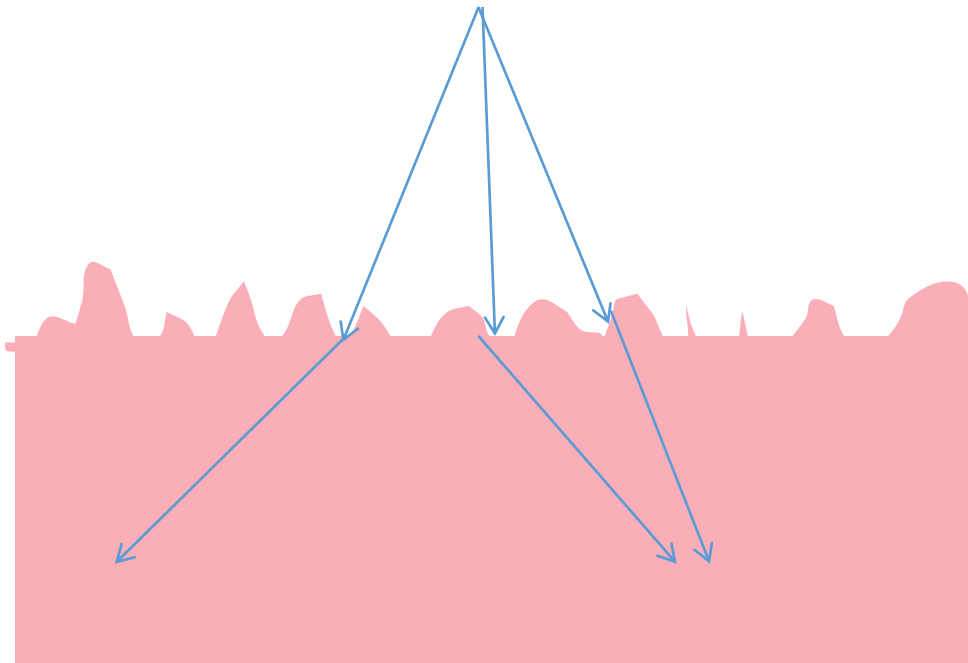


Angular-dependence



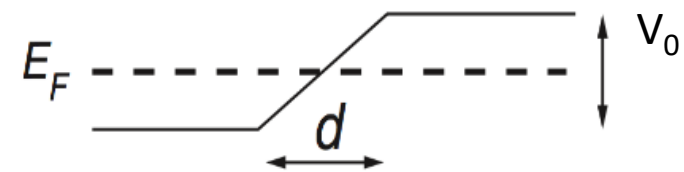
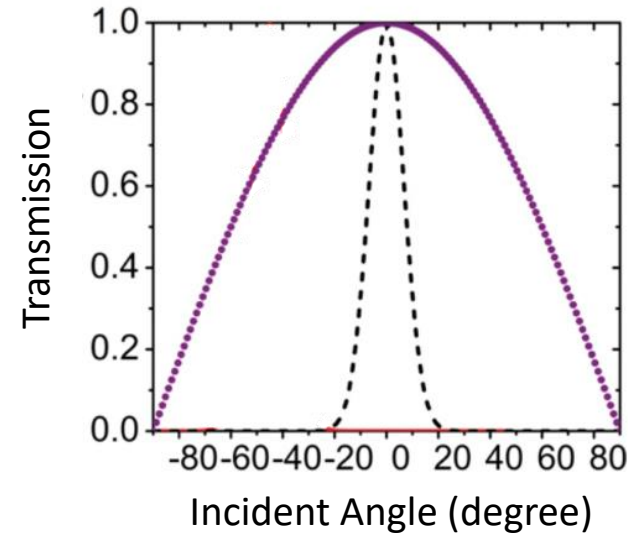
Challenges in achieving a sharp edge

Smooth junction edge
(compared with λ_F)



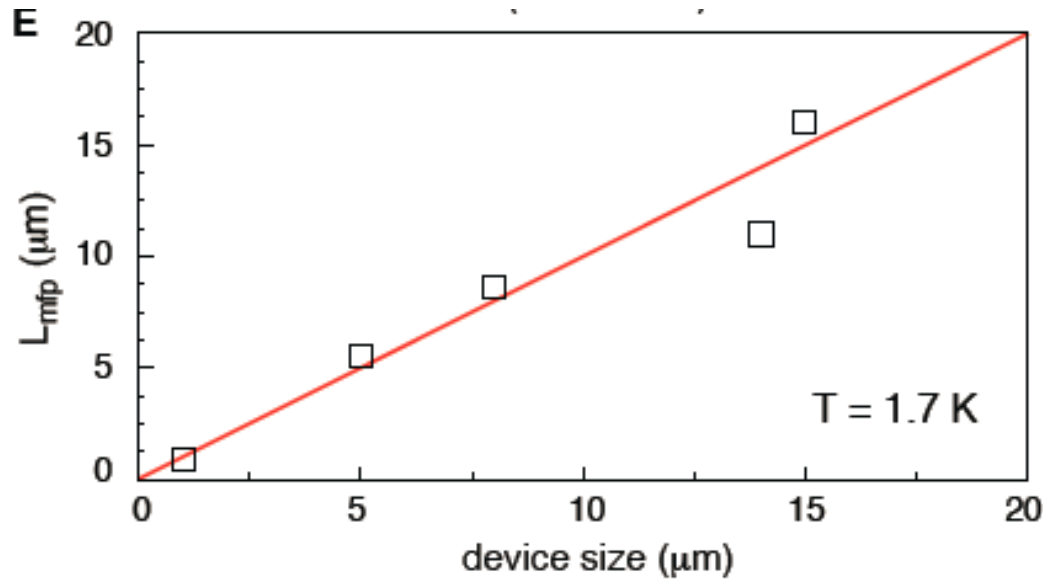
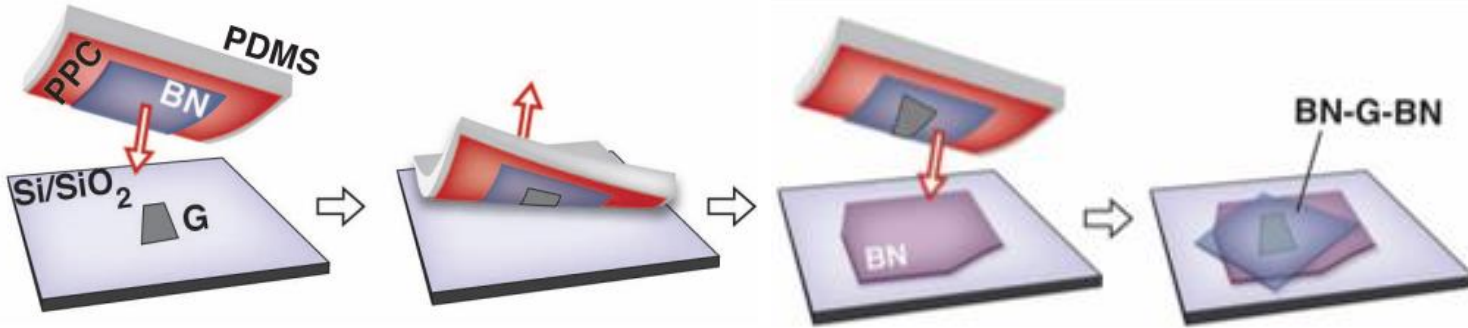
Rough edge refracts electron randomly

Angle dependent transmission
(sharp junction)

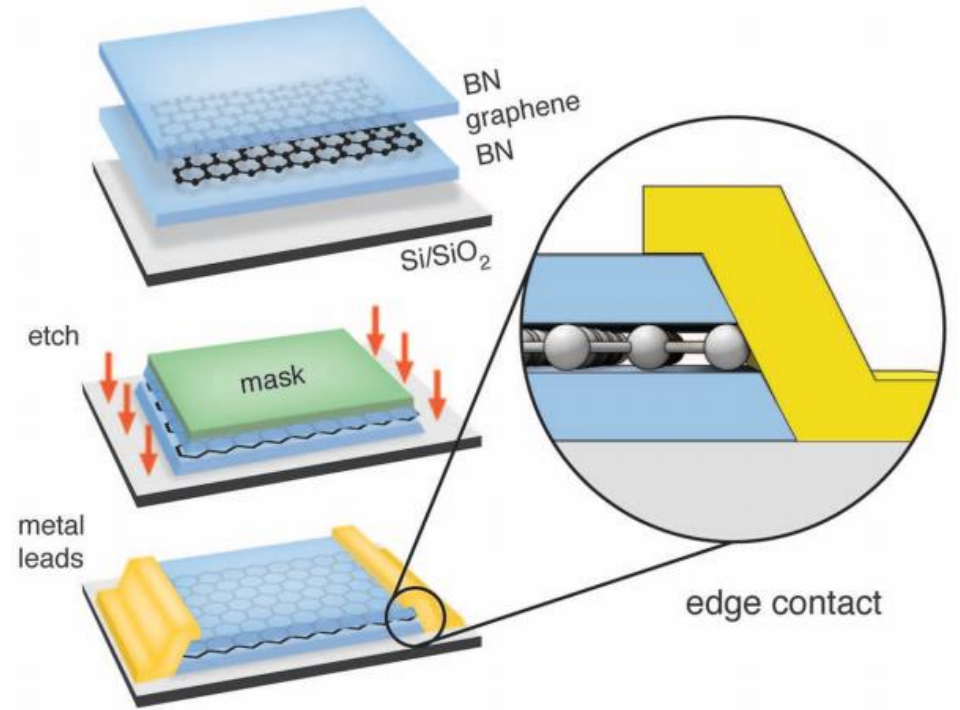


Advances in graphene device fabrication

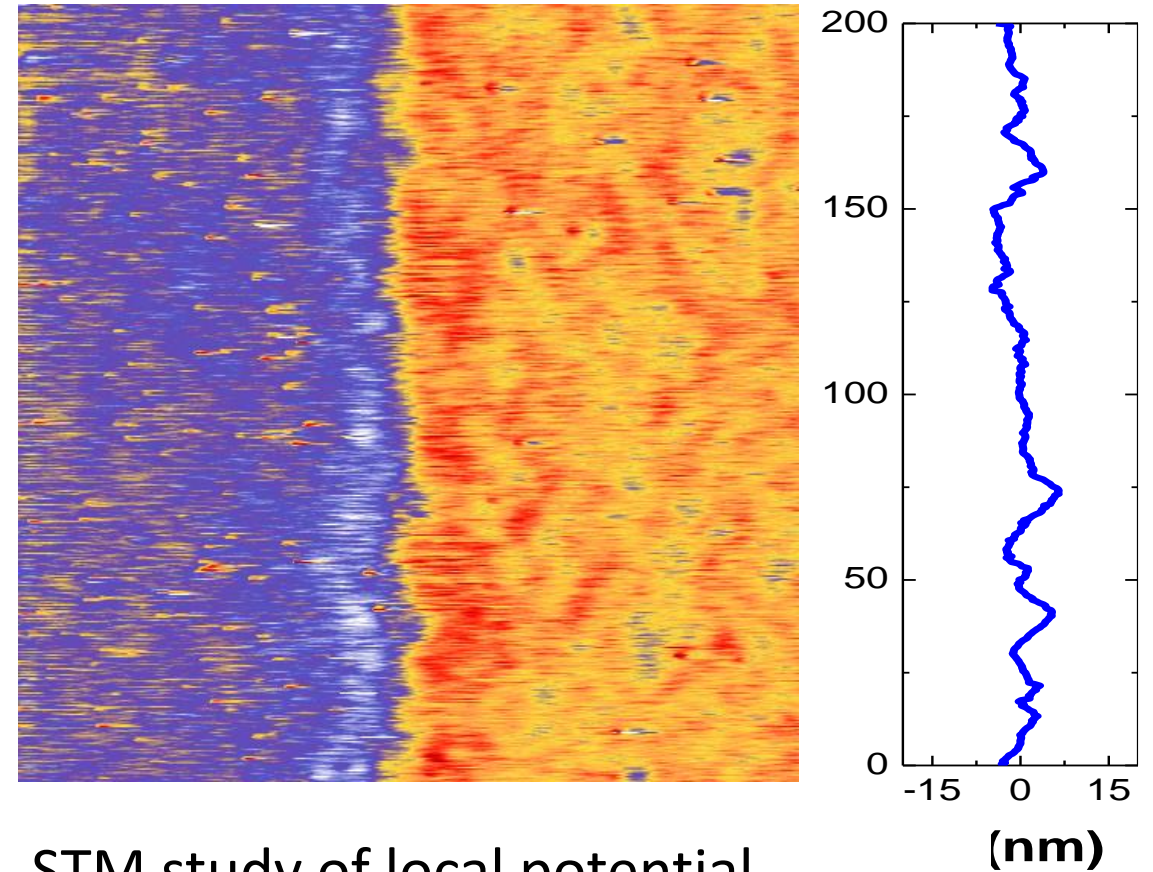
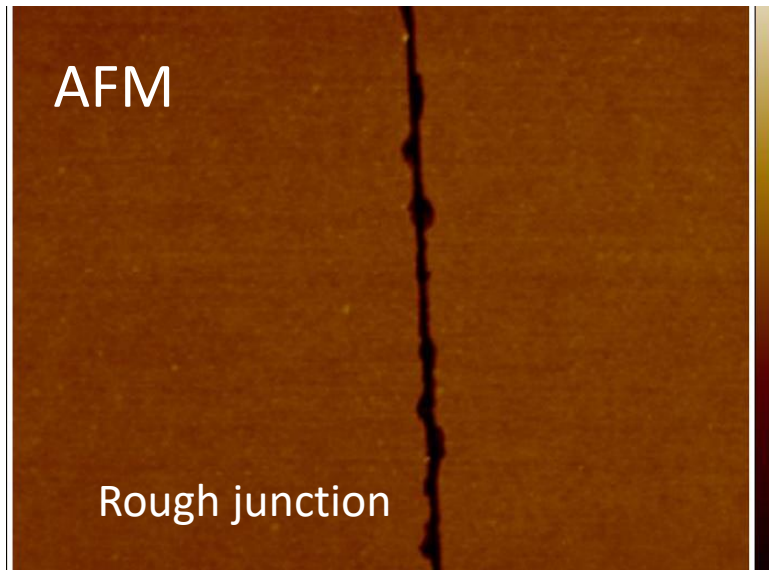
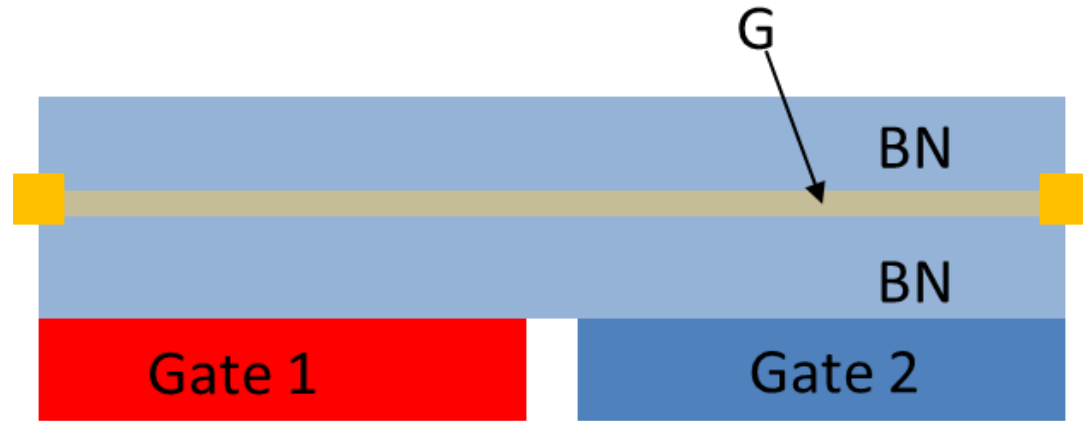
van der Waals Transfer



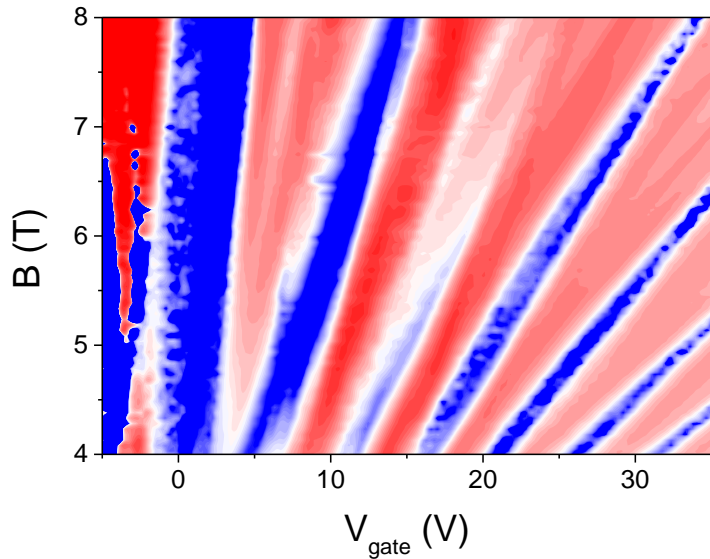
1D Edge Contacts



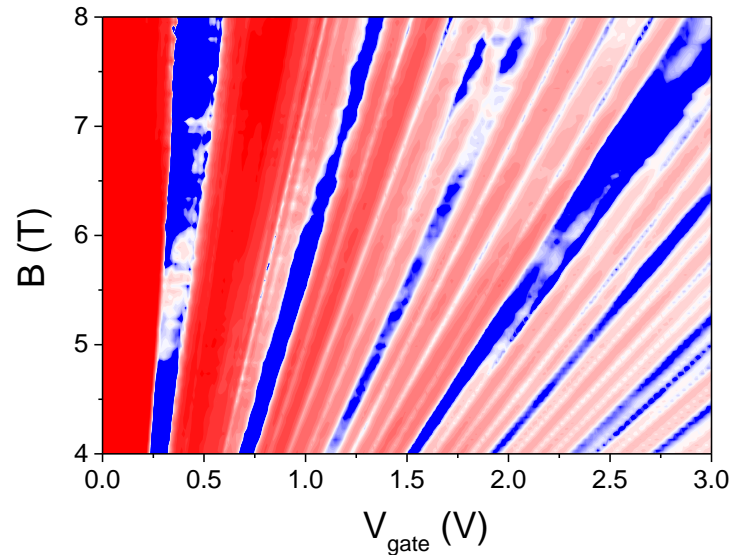
Metallic gates



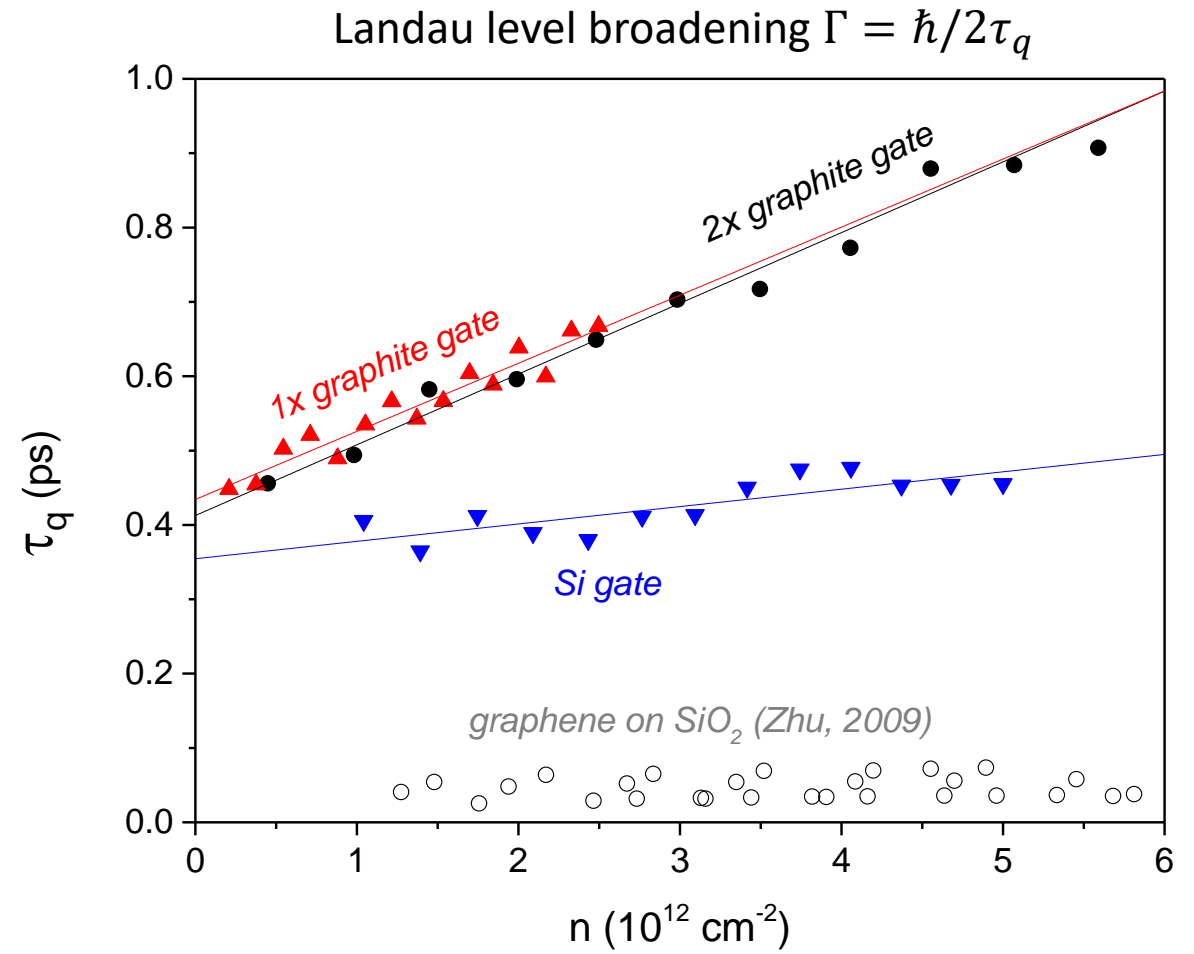
Metric for device quality



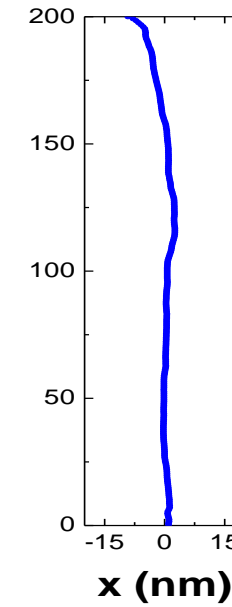
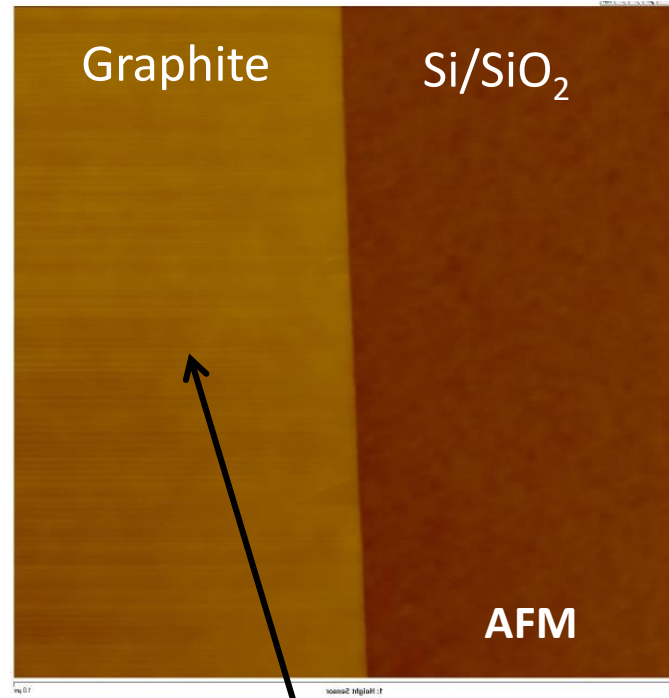
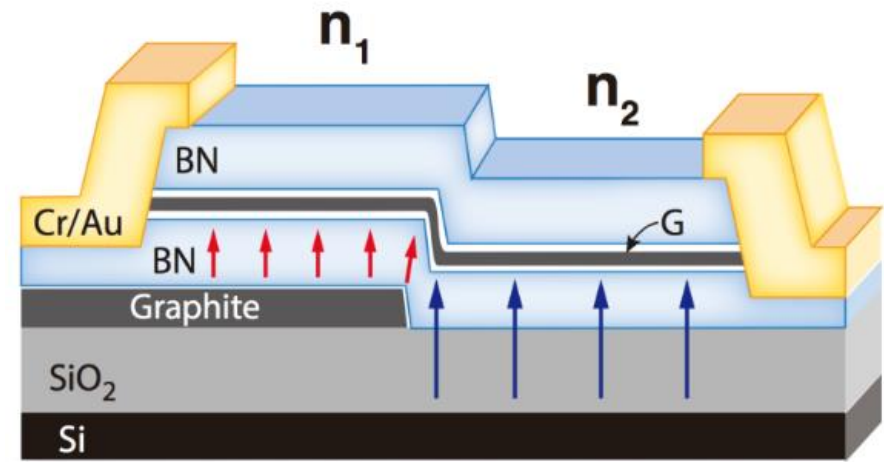
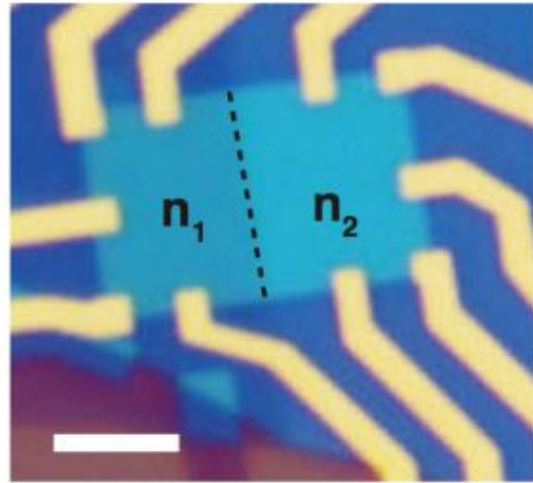
Silicon Gate



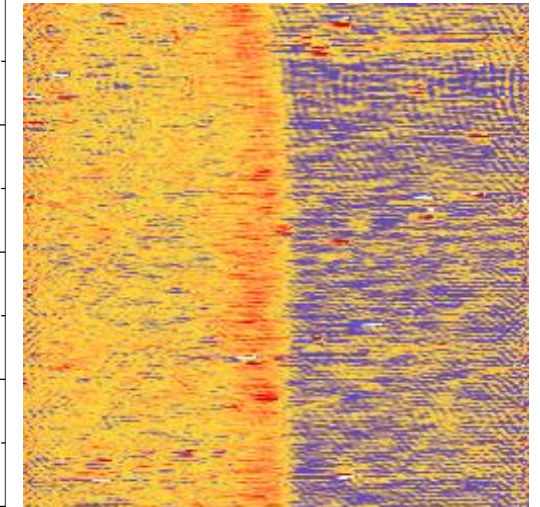
2x Graphite Gate



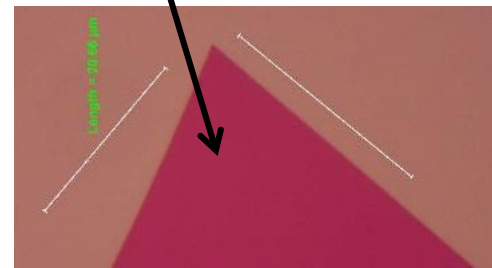
Straight edge junction



Smooth junction

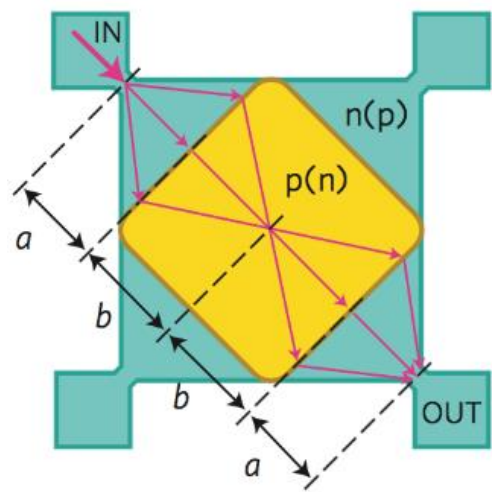
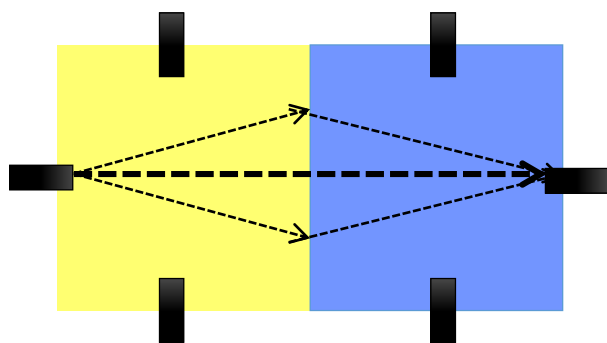


Zhu, X., et al. unpublished
STM

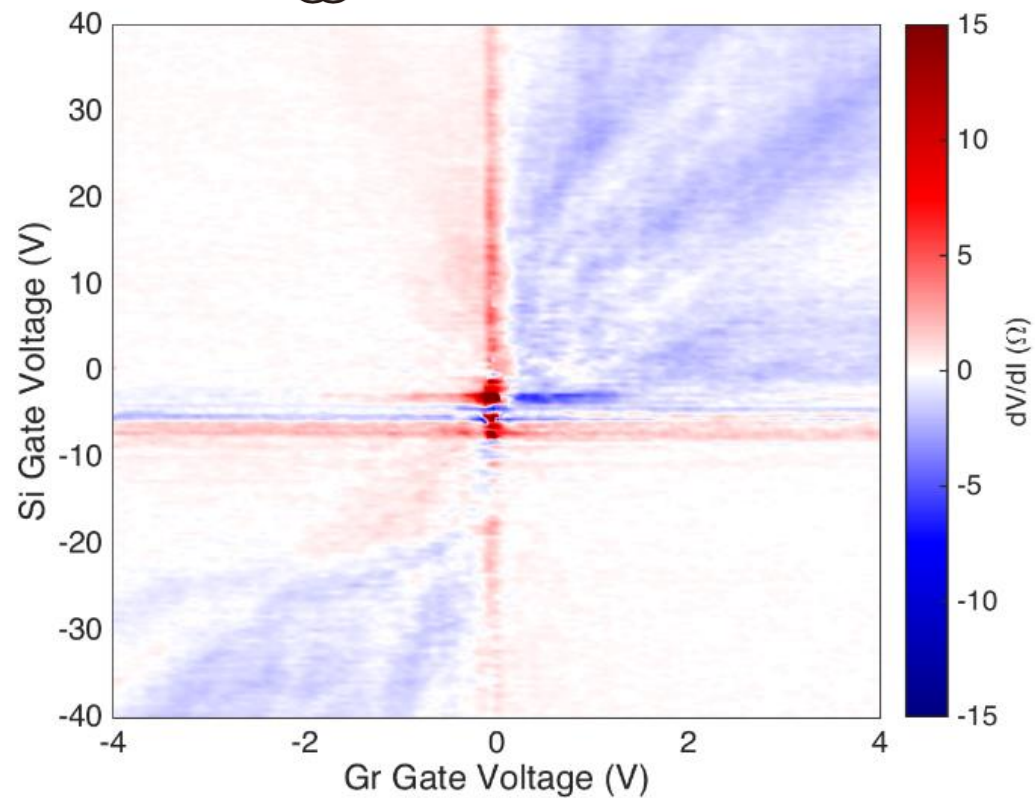
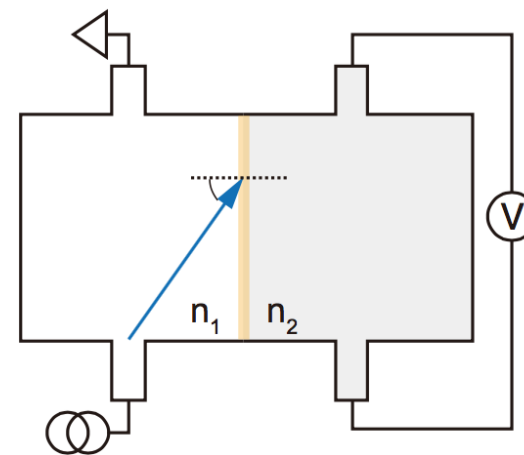


~ atomically smooth

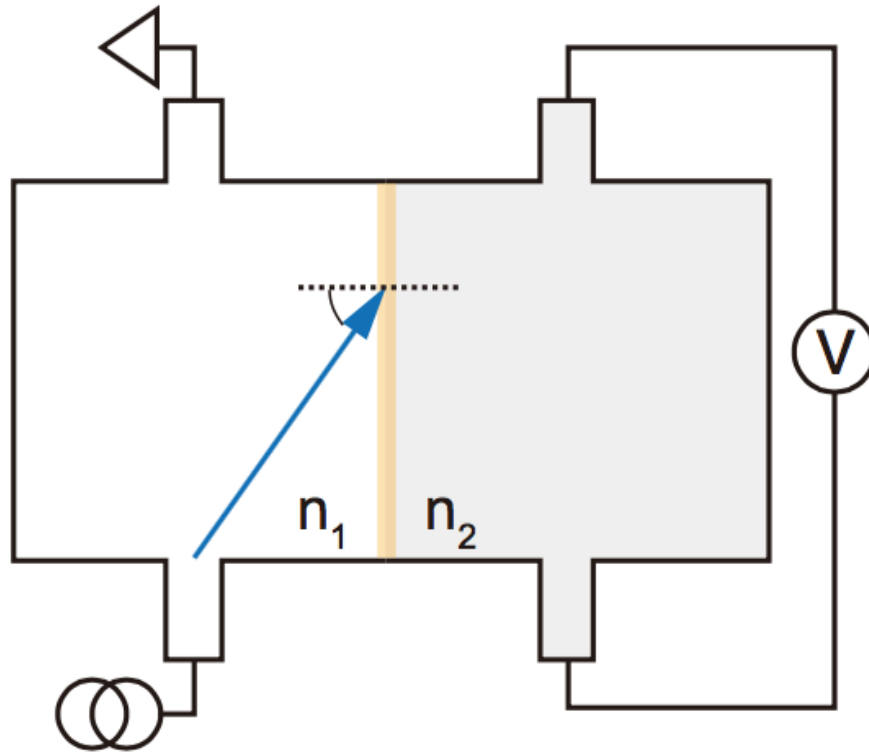
Measurement configuration



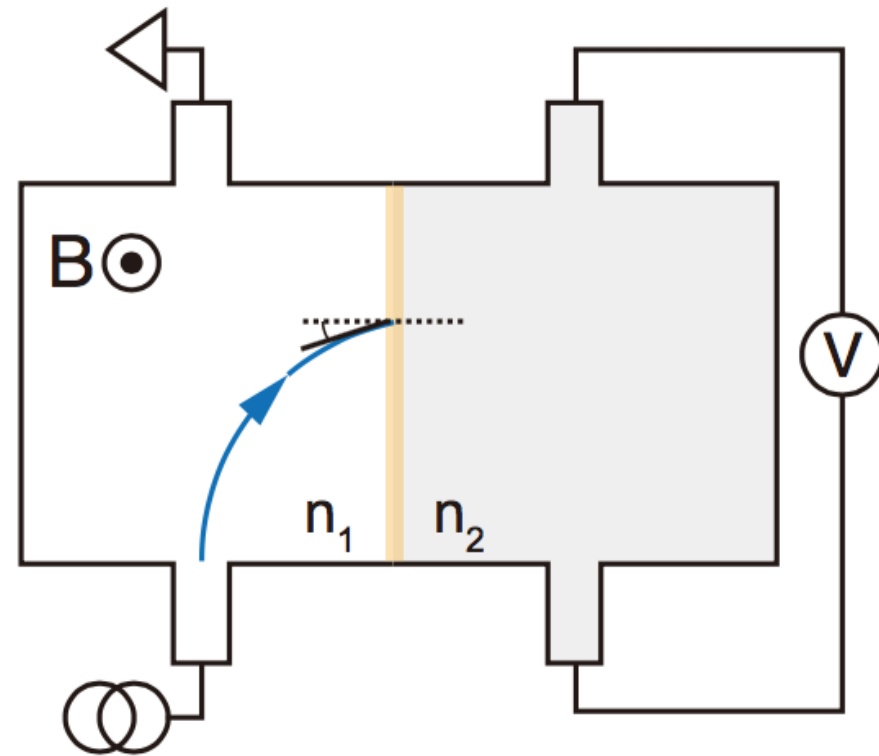
Large background



Achieving a smaller incident angle



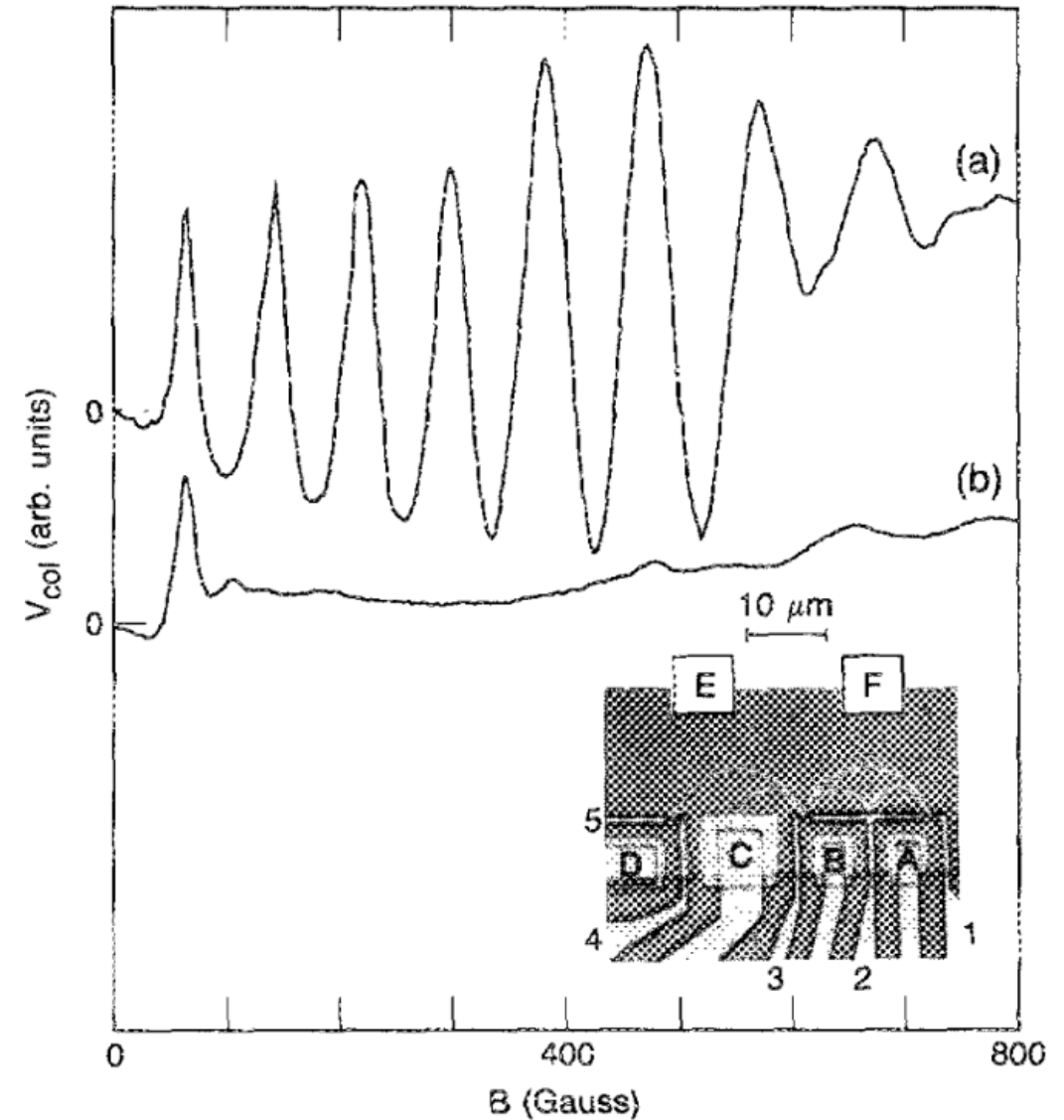
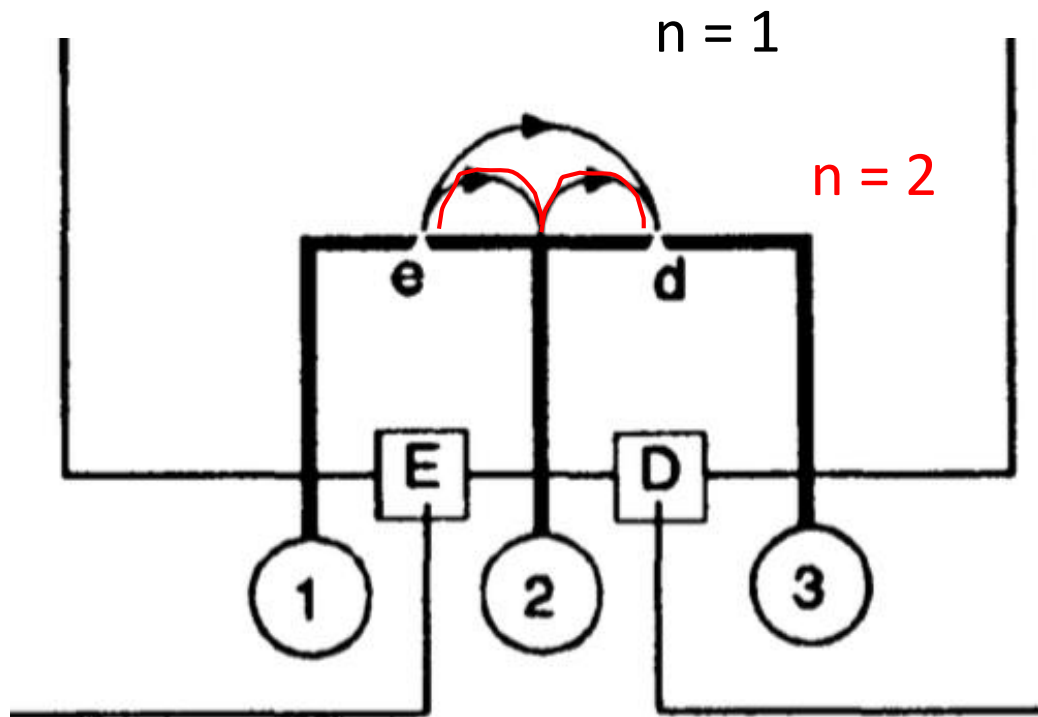
Zero magnetic field



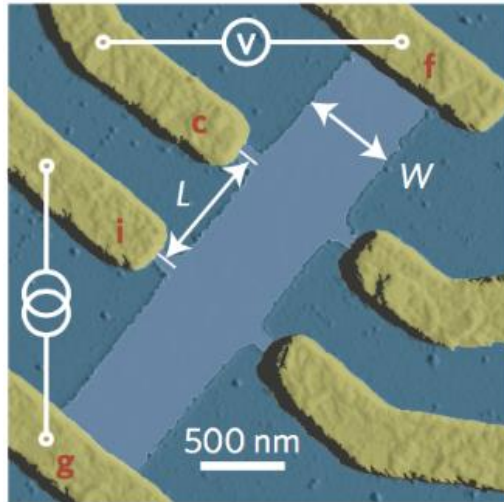
Transverse magnetic focusing (TMF)

Transverse magnetic focusing in 2DEGs

$$L = 2n \times R_{\text{cyclotron}} \quad n = 1, 2, 3 \dots$$



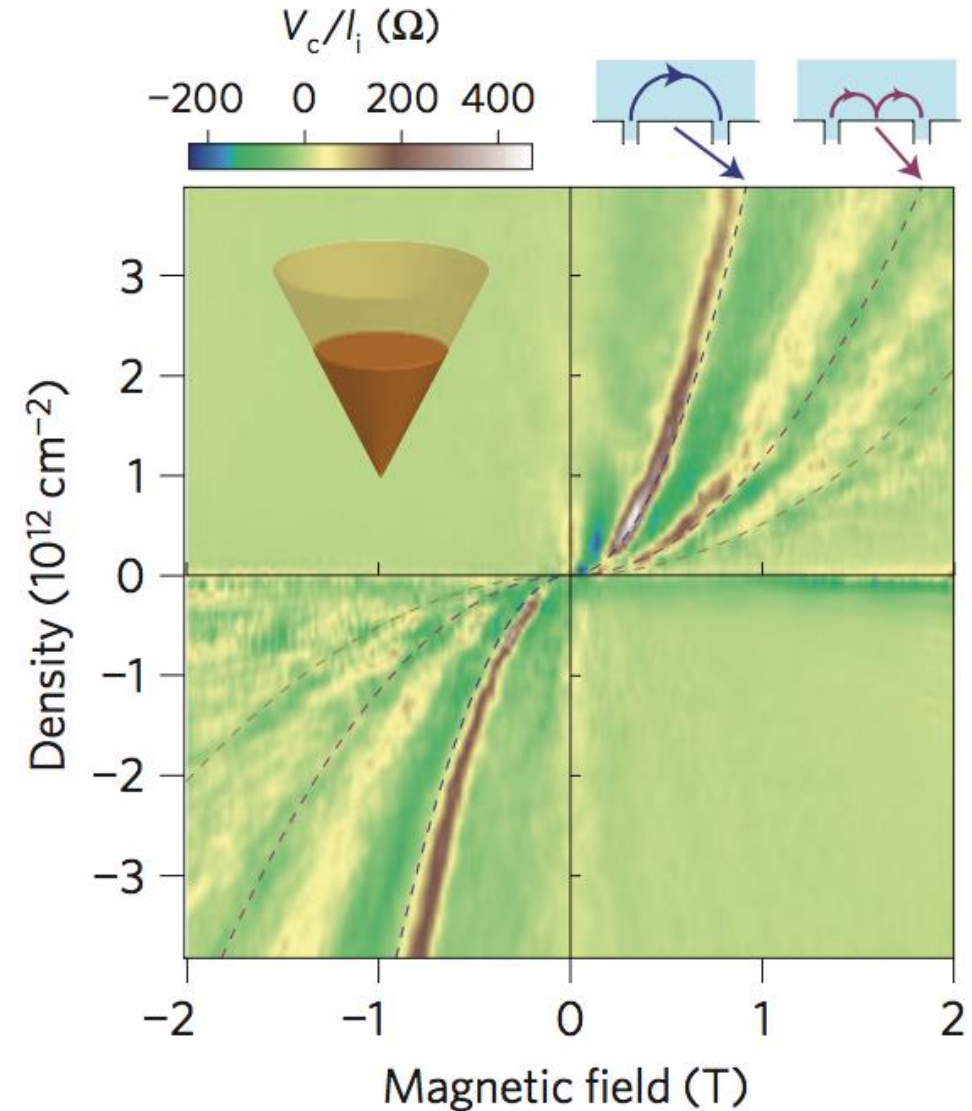
Transverse magnetic focusing in graphene



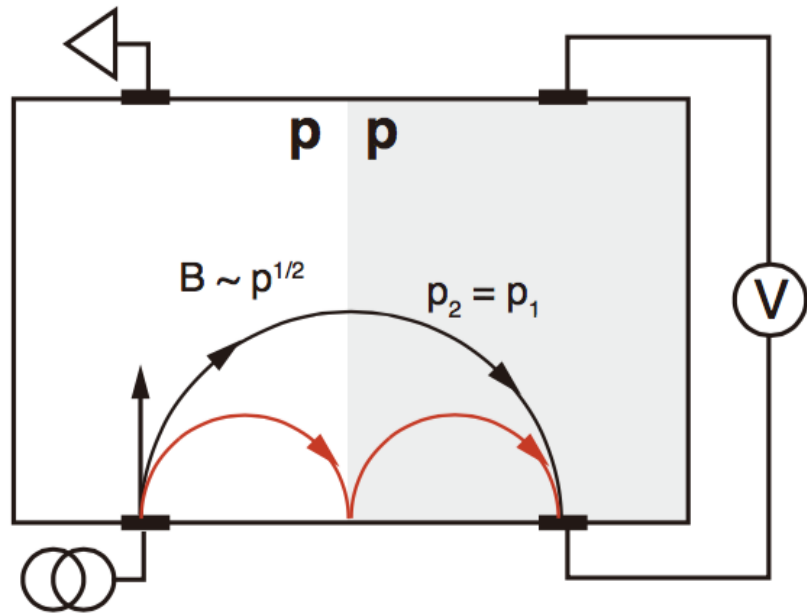
Resonance condition:

 p is integer

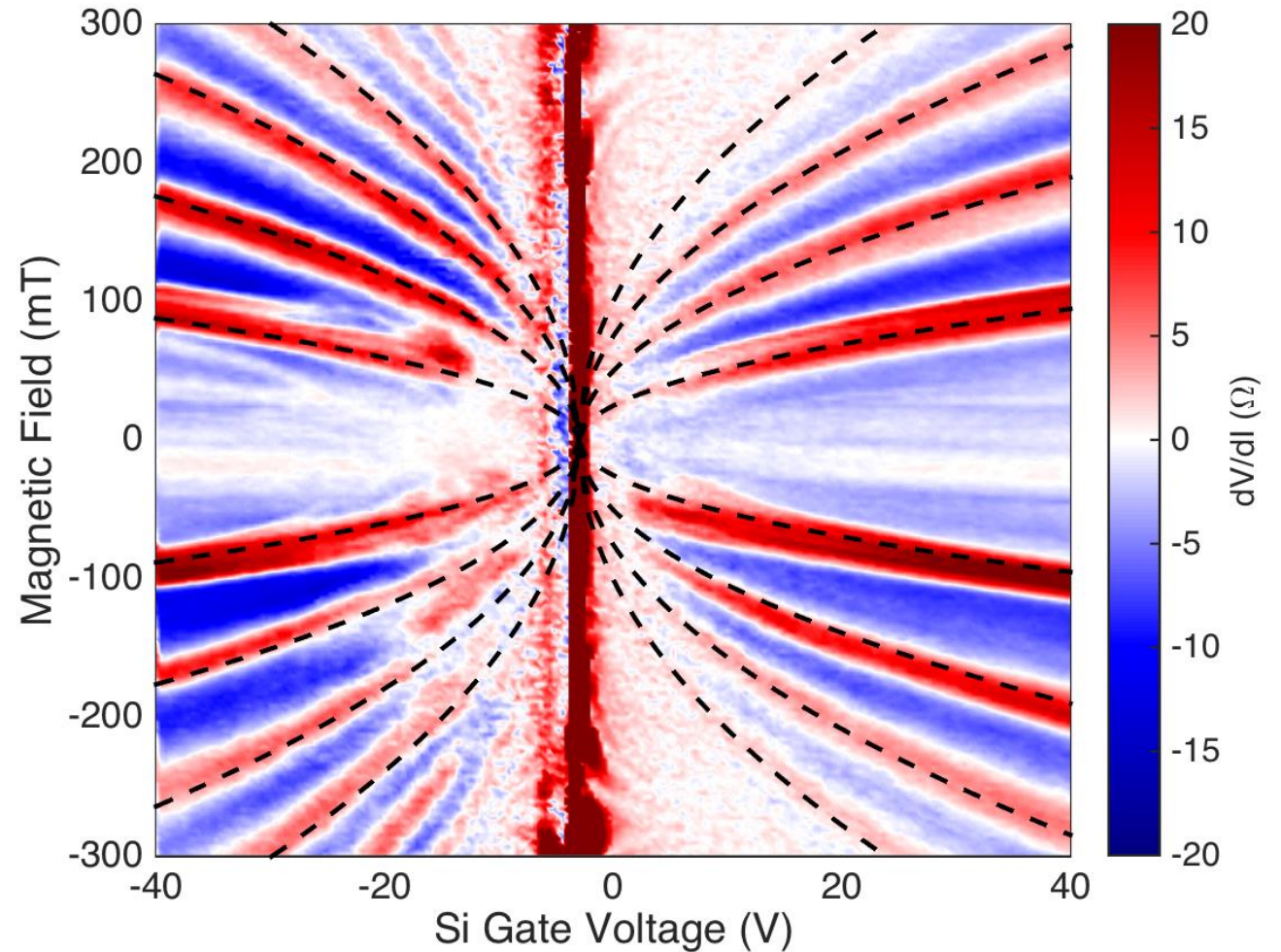
$$B_f^{(p)} = \left(\frac{2\hbar k_F}{eL} \right) p = \left(\frac{2\hbar \sqrt{\pi n}}{eL} \right) p$$



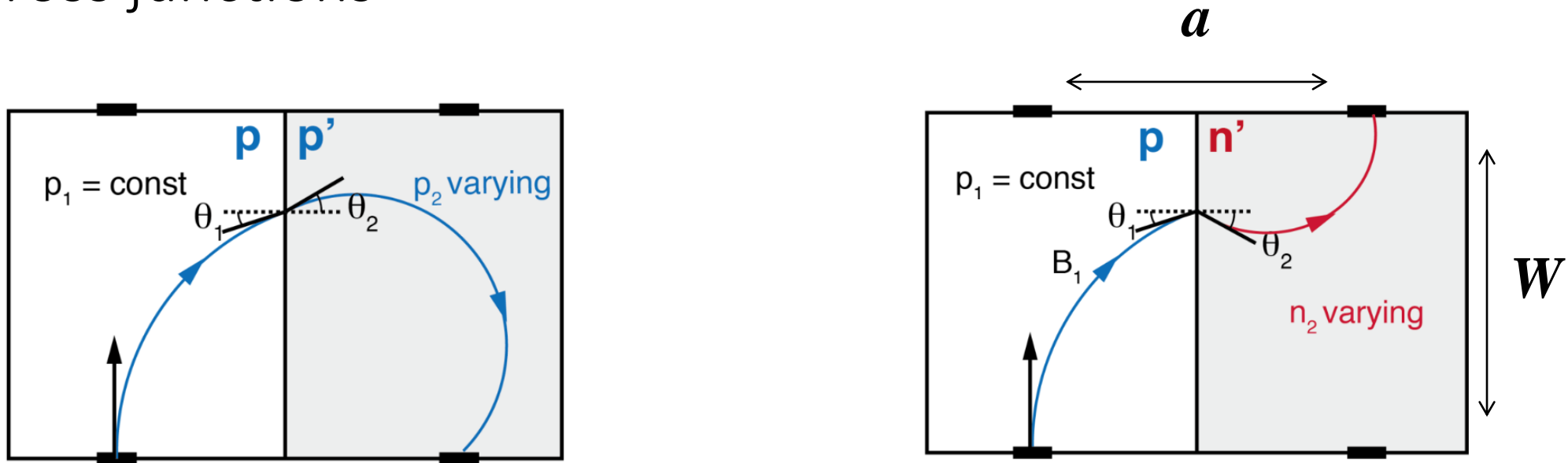
Matched density TMF



$$B = j \left(\frac{2\hbar\sqrt{\pi n}}{eL} \right) \quad j = 1, 2, 3, \dots$$



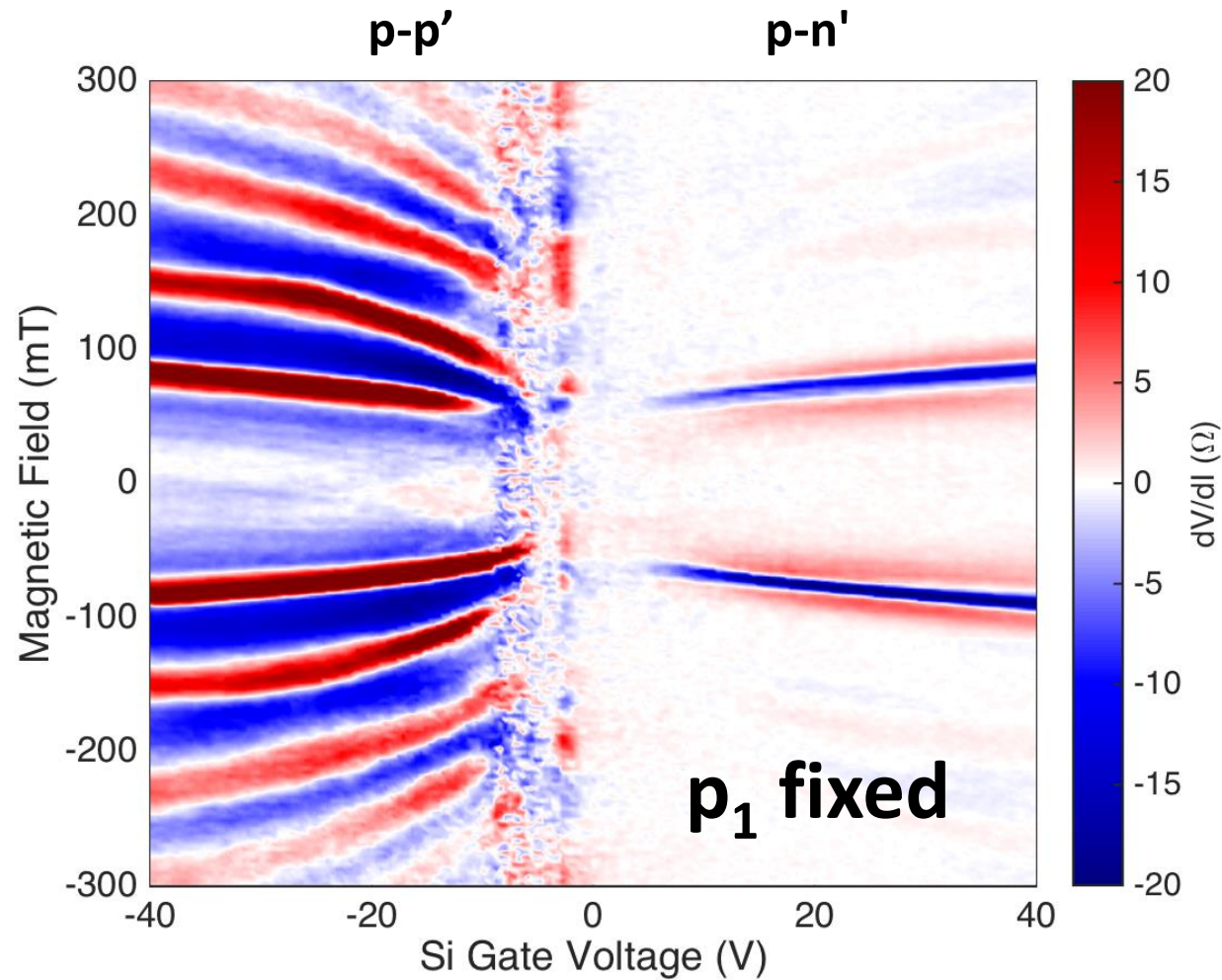
TMF across junctions



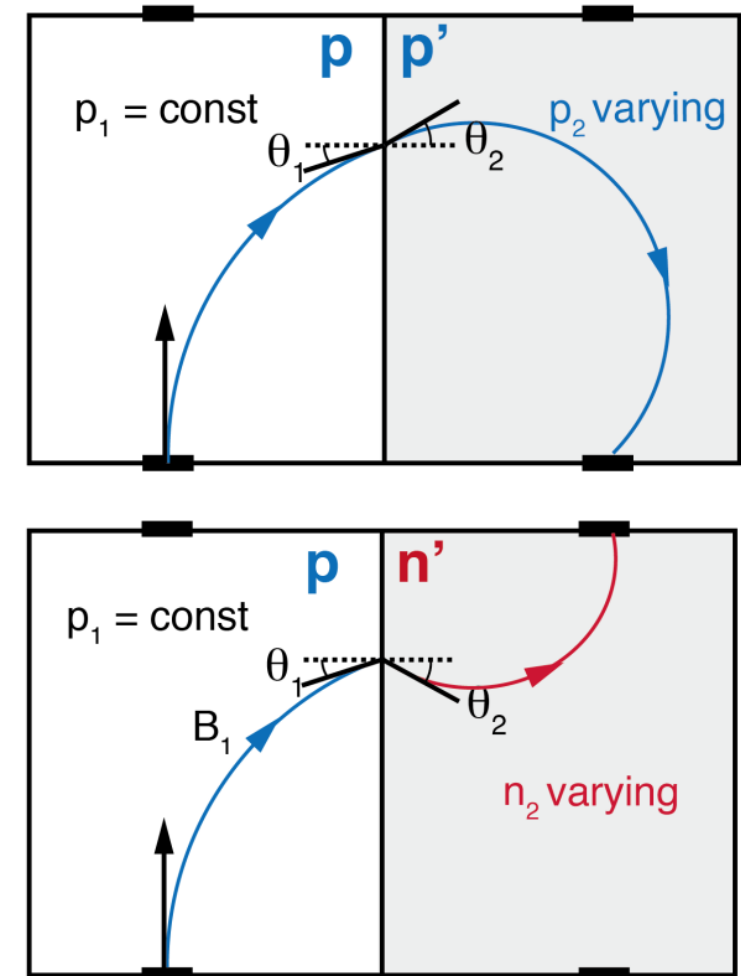
$$\mathbf{p-p'} \quad \sqrt{1 - \frac{n_1}{n_2} \left(\frac{R_1 - a}{R_1} \right)^2} \sqrt{2R_1 a - a^2} + \sqrt{\frac{n_1}{n_2}} \cdot \frac{R_1 - a}{R_1} \cdot a - a \sqrt{\frac{n_1}{n_2}} = 0$$

$$\mathbf{p-n} \quad \sqrt{1 - \frac{n_1}{n_2} \left(\frac{R_1 - a}{R_1} \right)^2} \left(W - \sqrt{2R_1 a - a^2} \right) + \sqrt{\frac{n_1}{n_2}} \cdot \frac{R_1 - a}{R_1} \cdot a - \frac{(W - \sqrt{2R_1 a - a^2})^2 + a^2}{2R_1} \sqrt{\frac{n_1}{n_2}} = 0$$

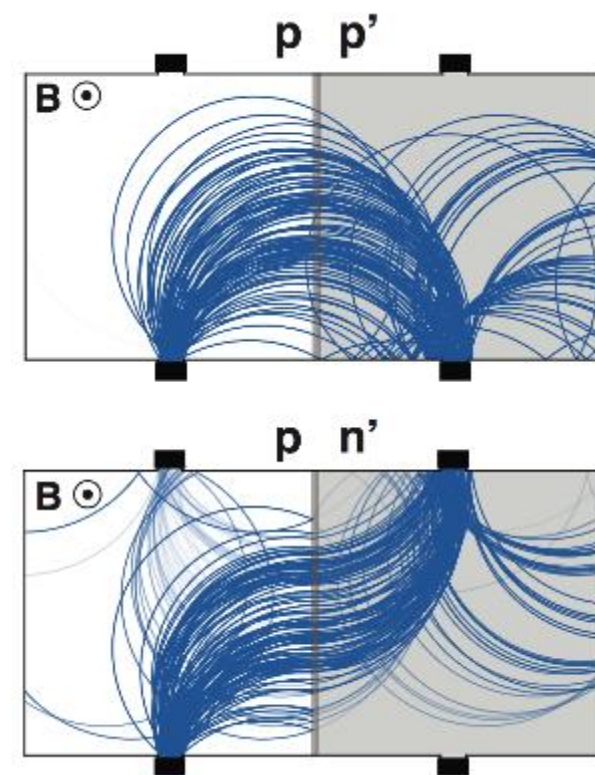
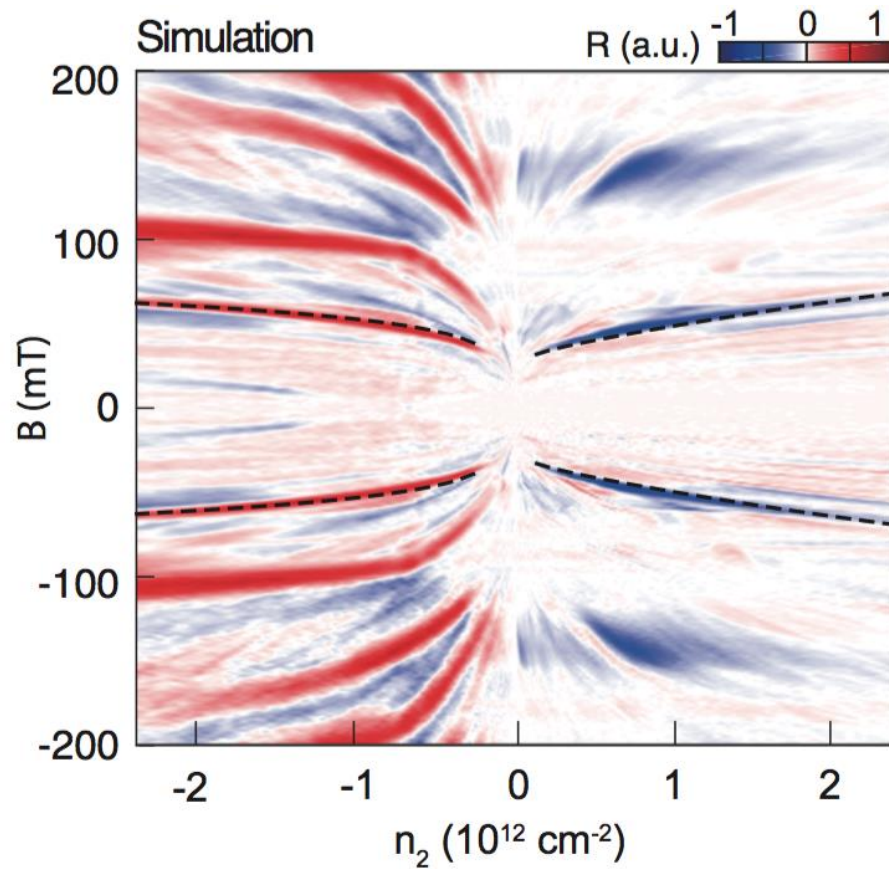
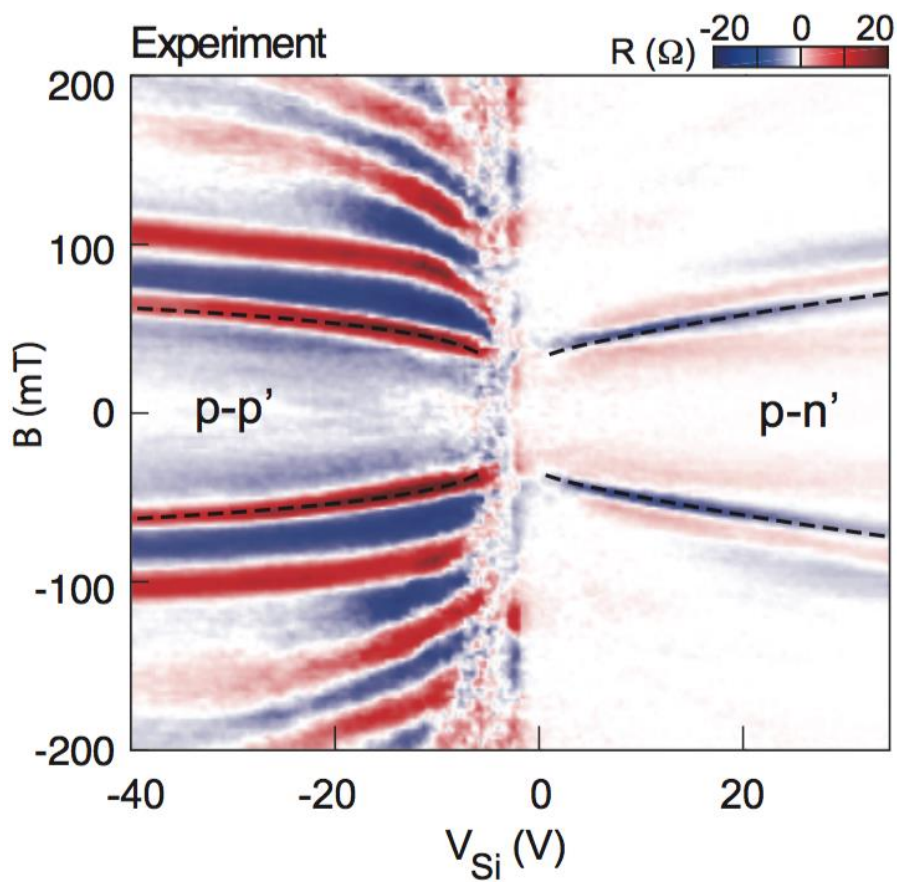
TMF across junctions



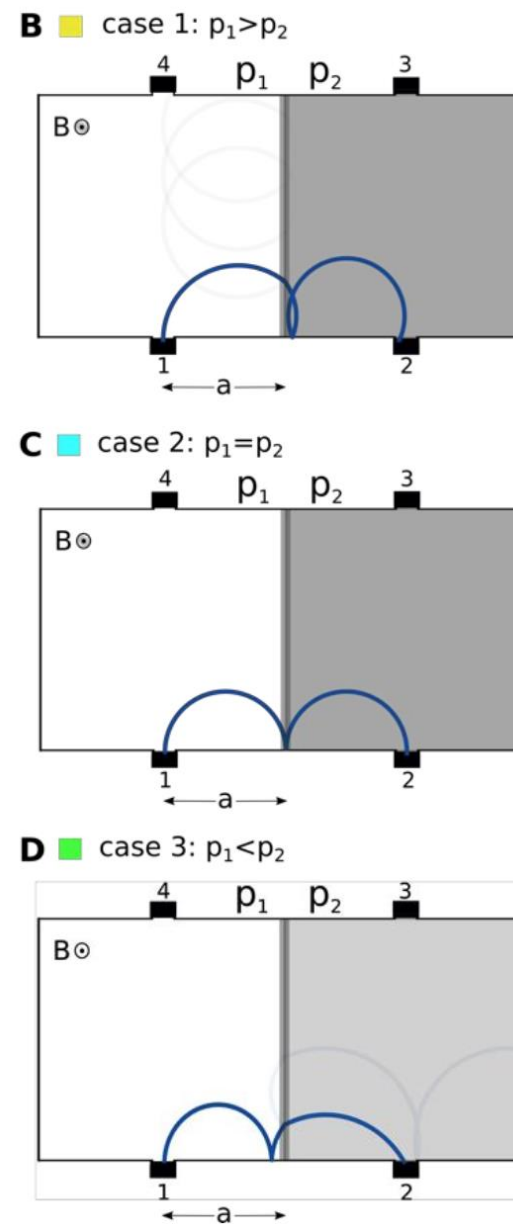
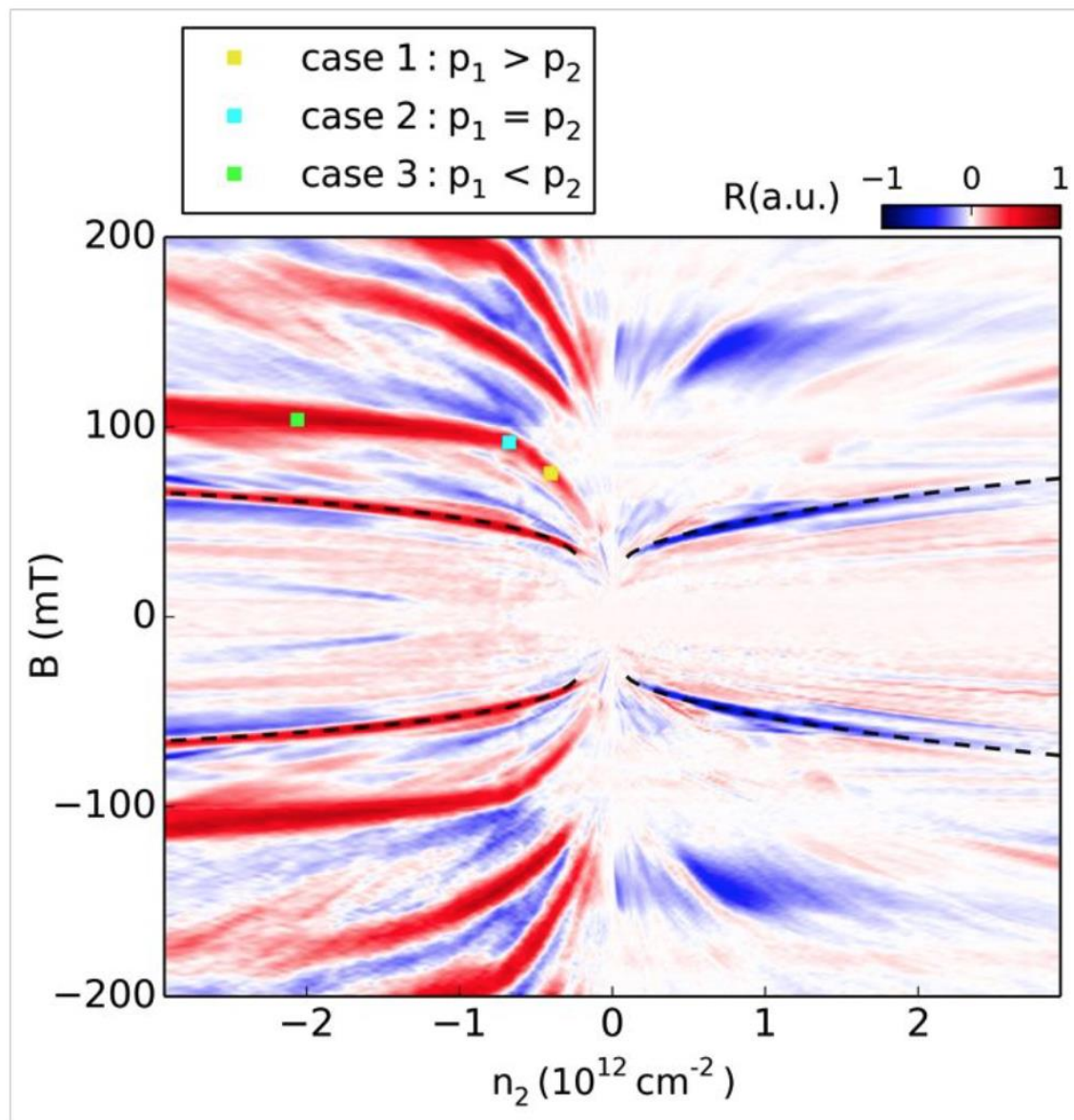
$$p_1 = 1.61e12 \text{ cm}^{-2}$$



Experiment vs. Simulation

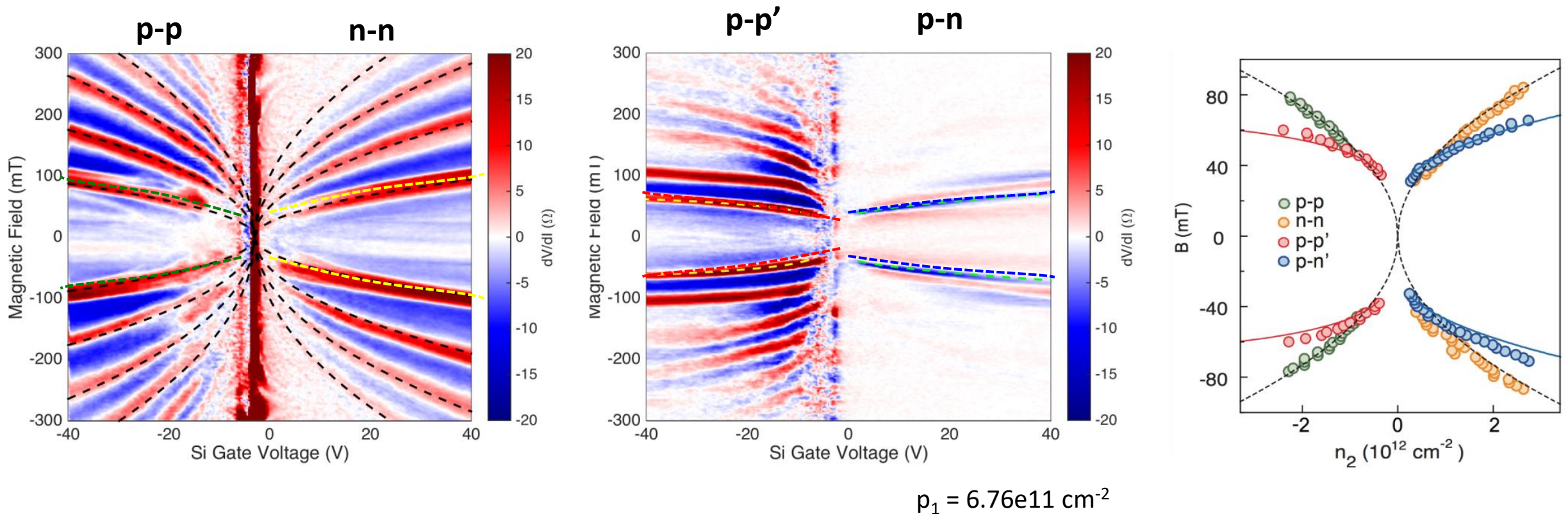


Explanation of kinks



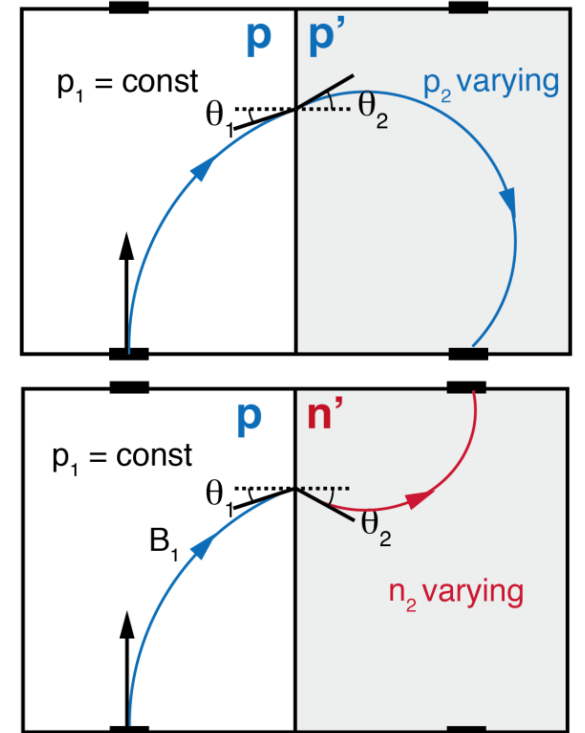
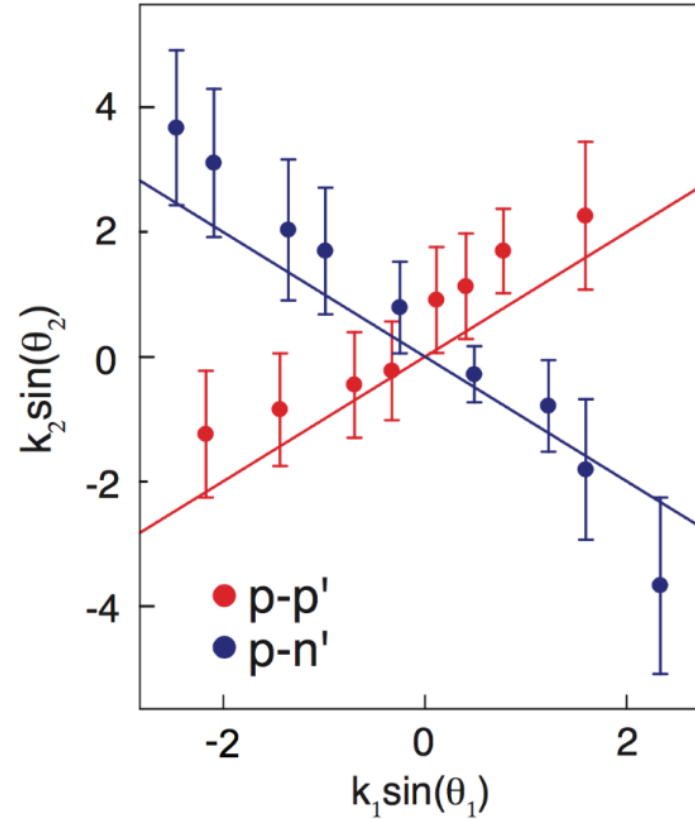
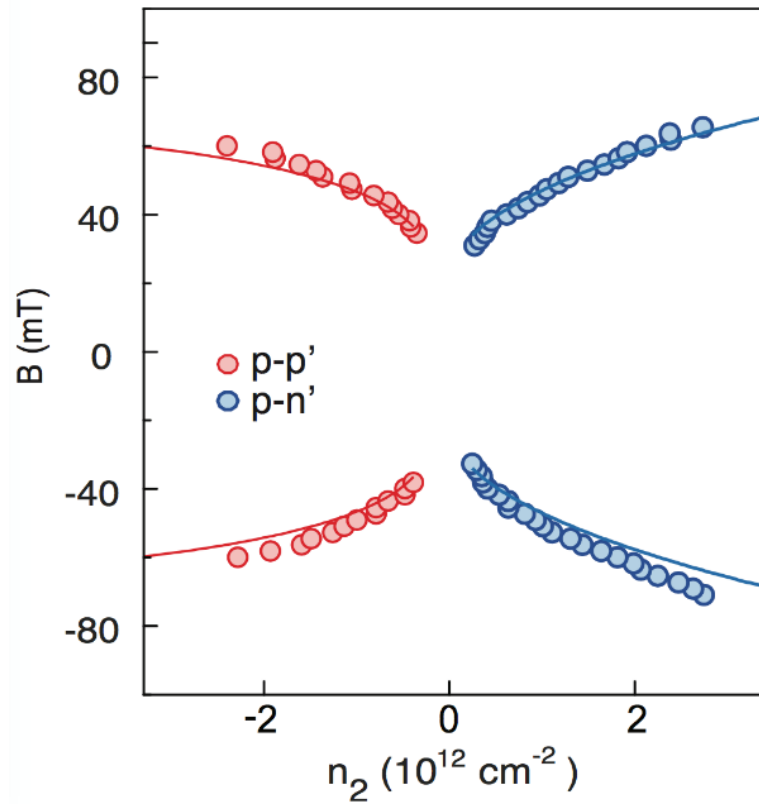
Compare different modes

Extract 1st order peaks:

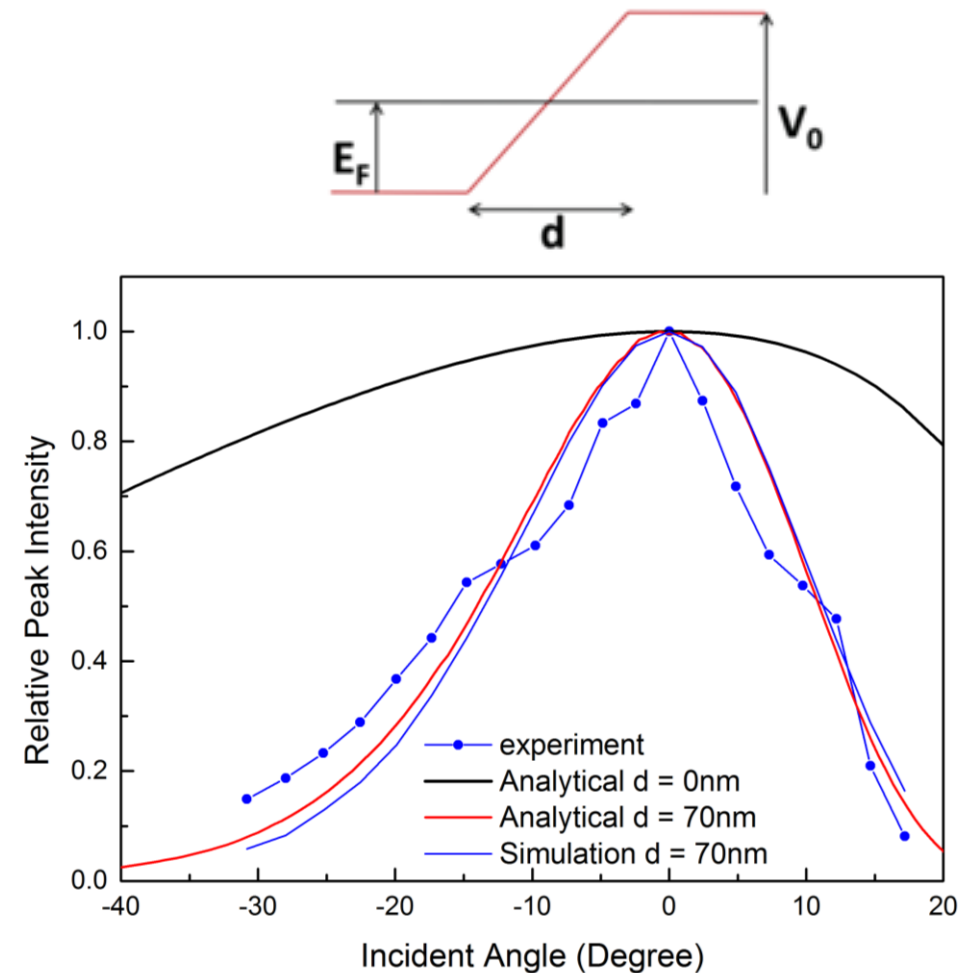
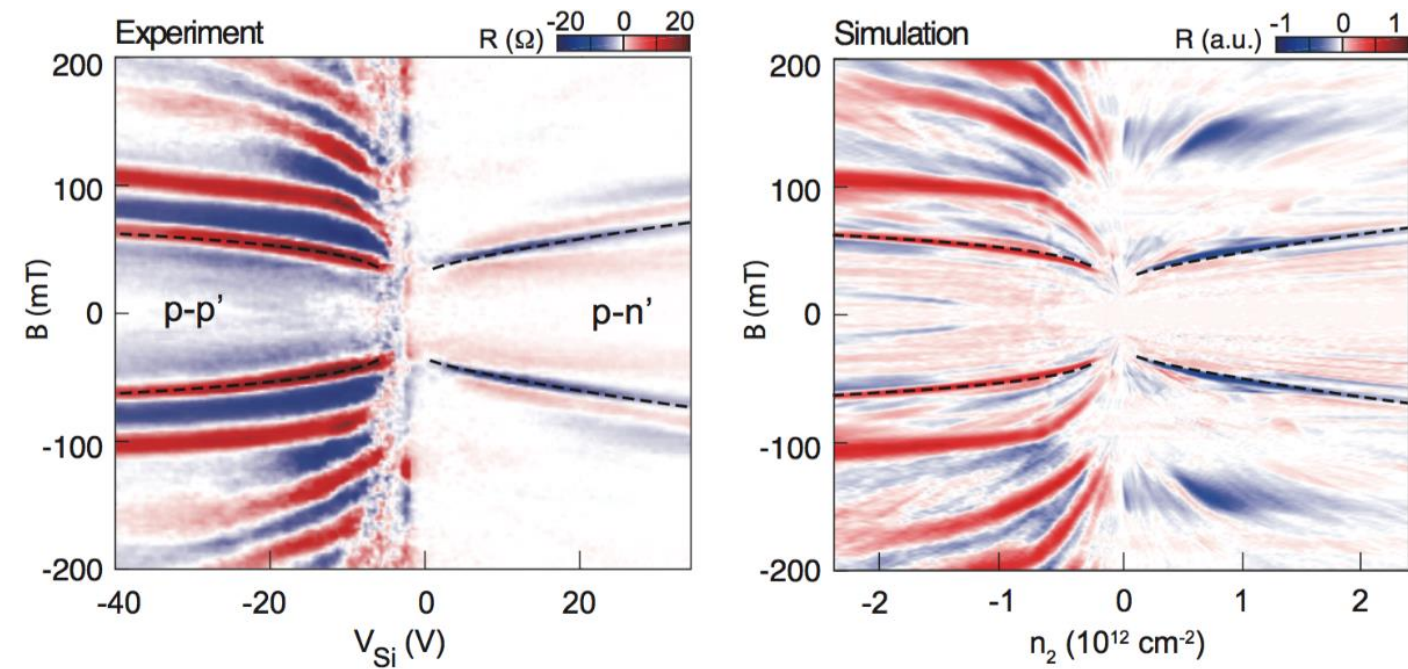


Snell's law for ballistic electrons

$$k_1 \sin \theta_1 = \pm k_2 \sin \theta_2$$



Angular dependent transmission

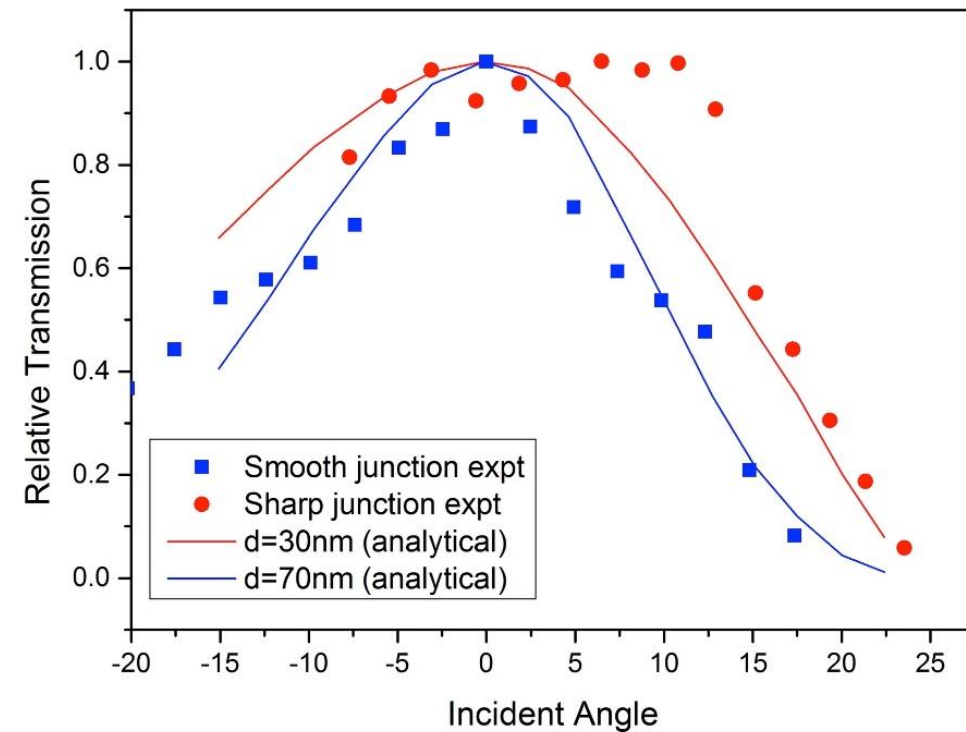
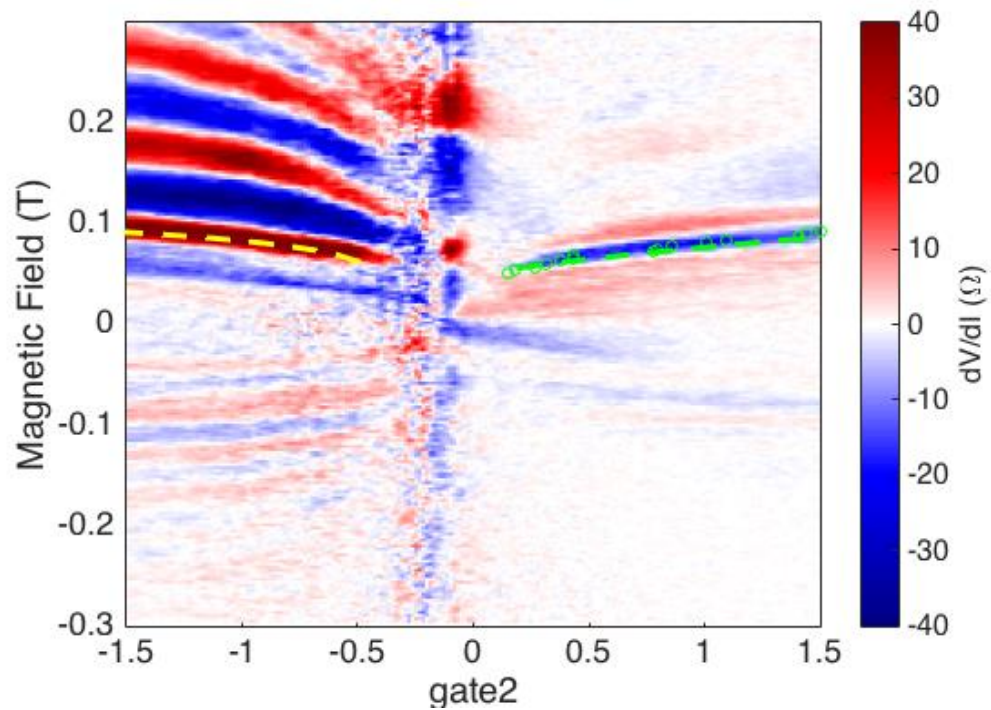
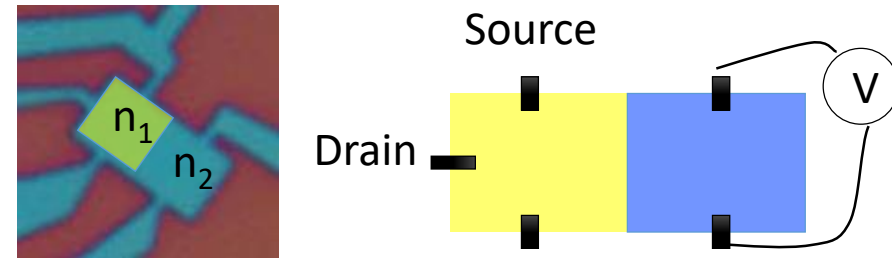
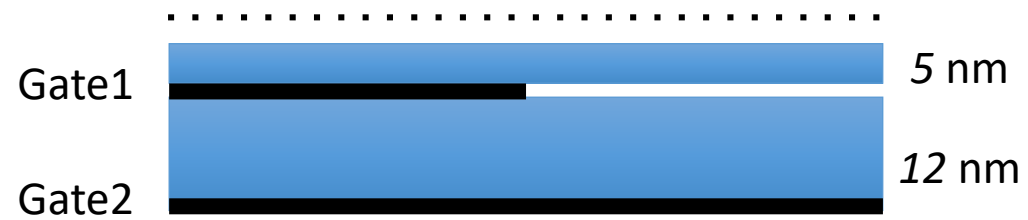


$$T = \left[\frac{\cos(\theta_1) \cos(\theta_2)}{\cos^2\left(\frac{\theta_1 + \theta_2}{2}\right)} \right] e^{-\pi \hbar v_f k_f^2 d \sin^2(\theta_i) / V_0}$$

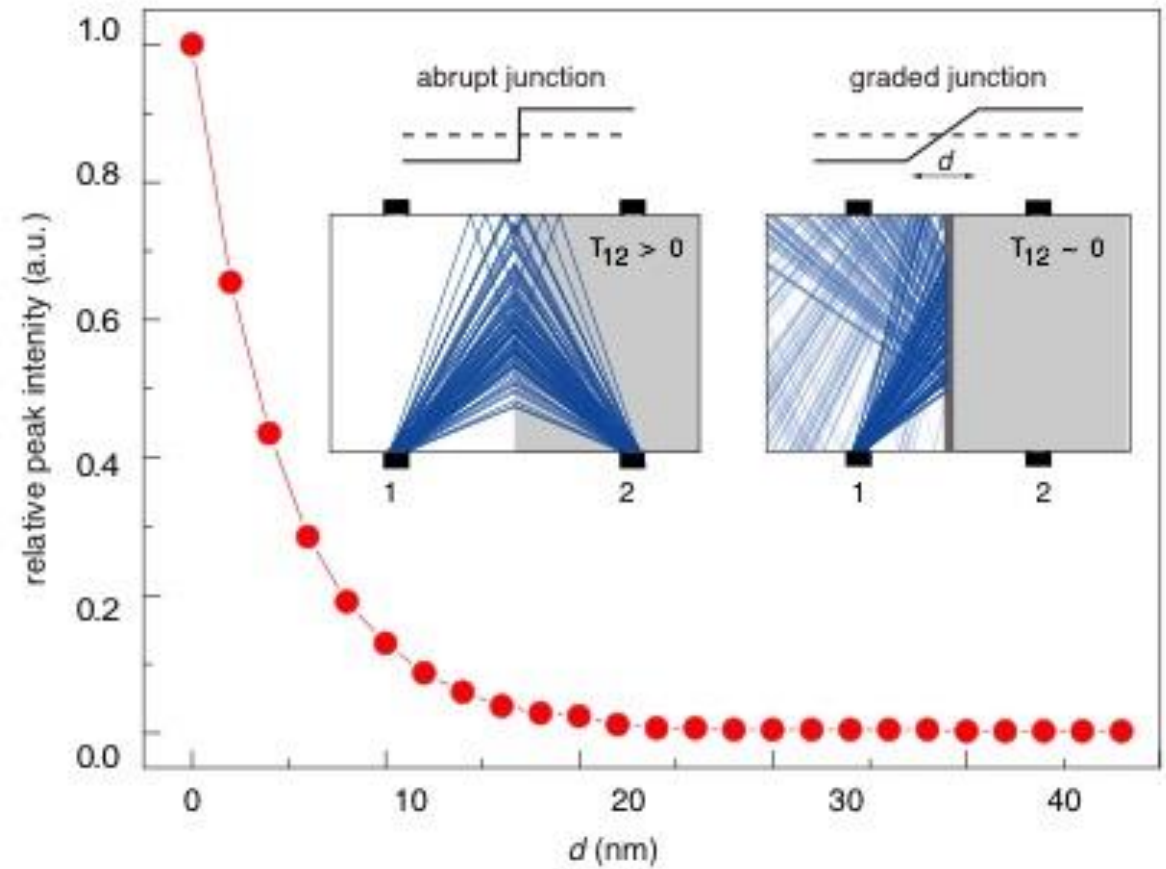
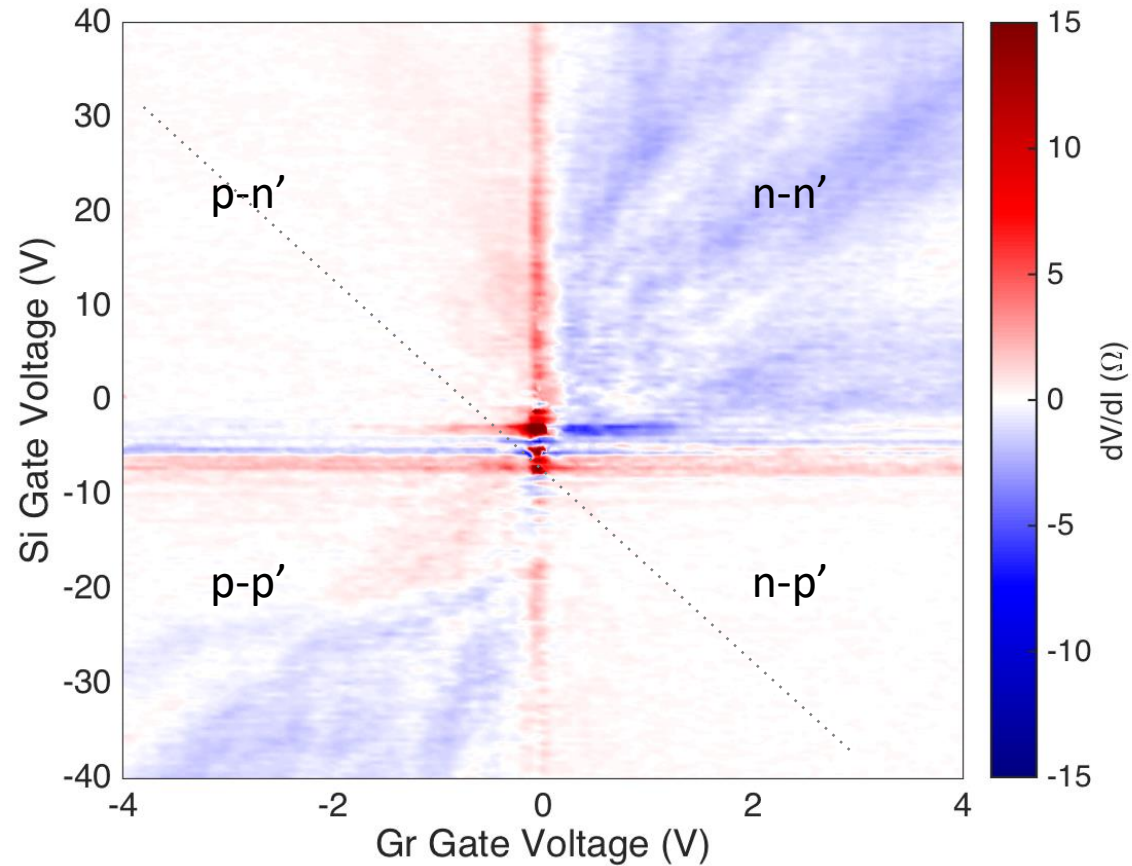
S. Chen, et al. *Science* (2016).

Sajjad, Redwan N., et al. *Phys. Rev. B* **86** (2012): 155412.

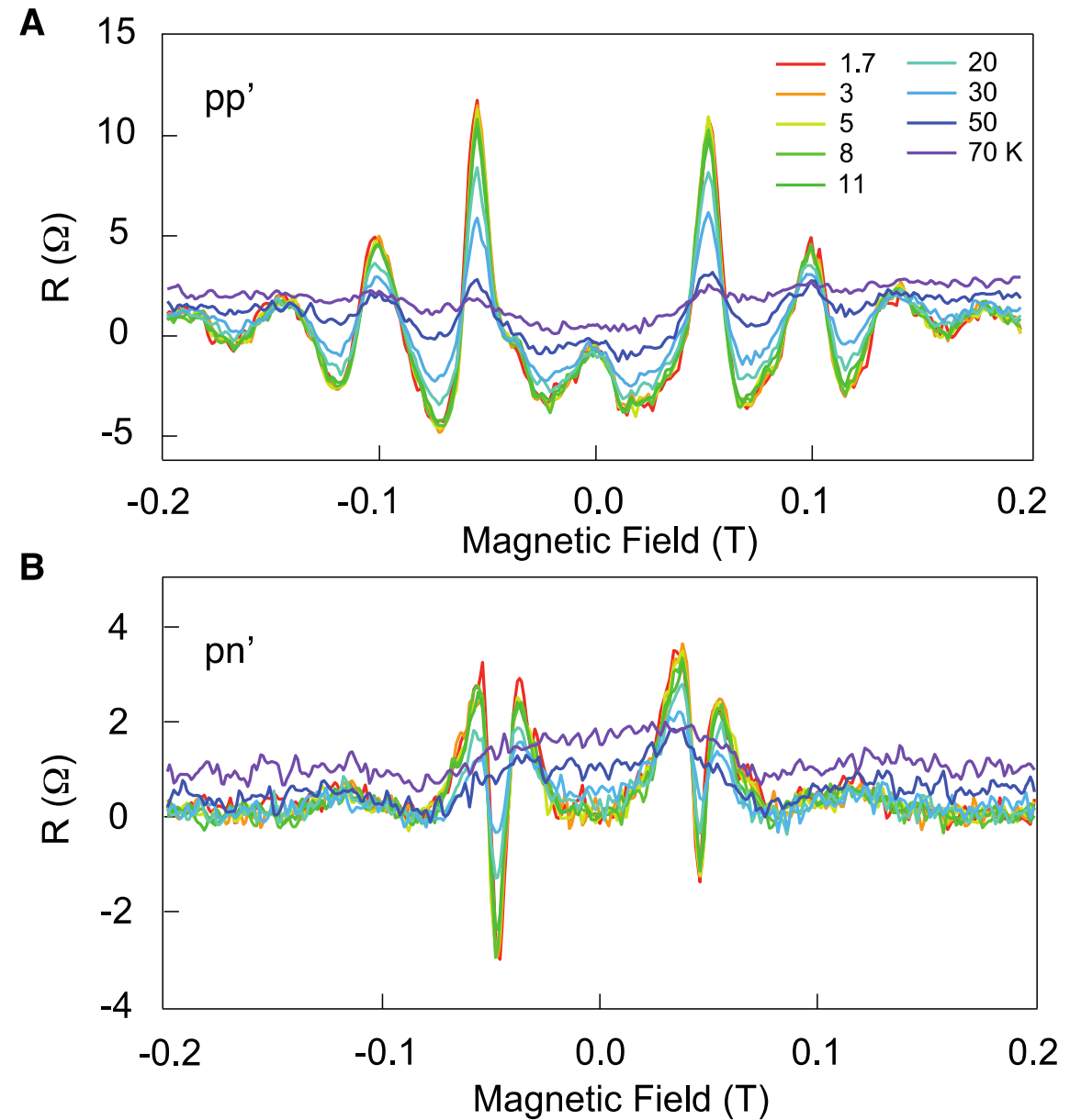
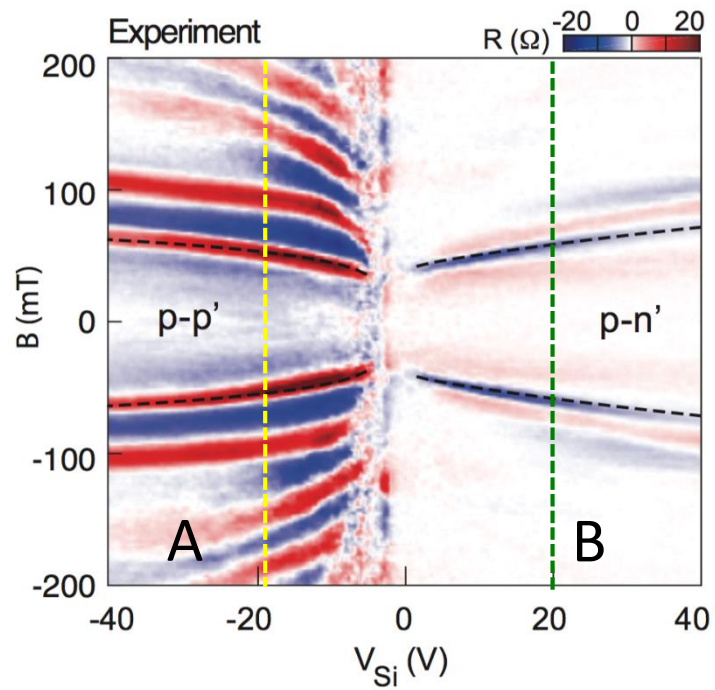
Toward sharper junctions



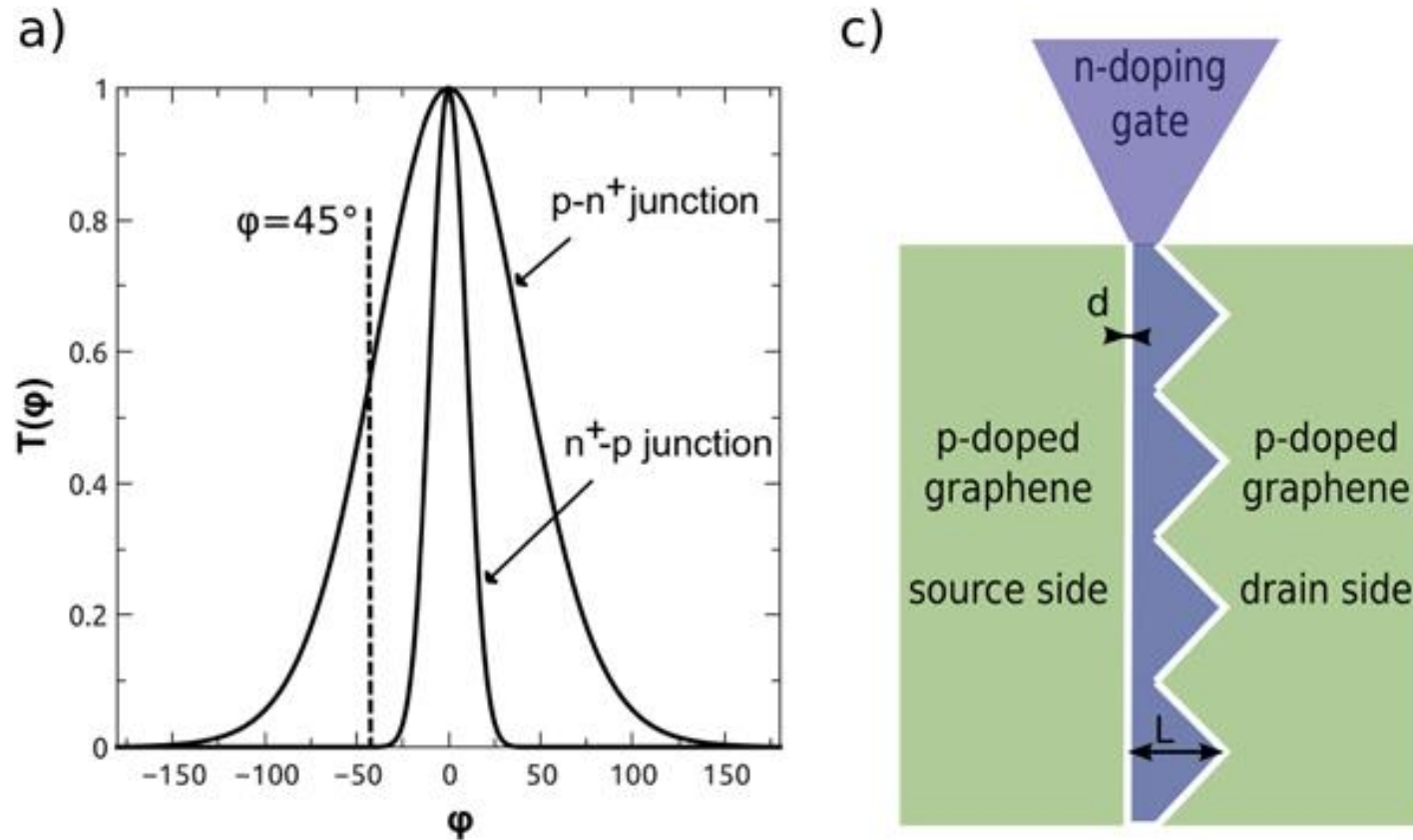
Back to zero field



Room temperature devices



Challenges with ballistic split-gate transistors

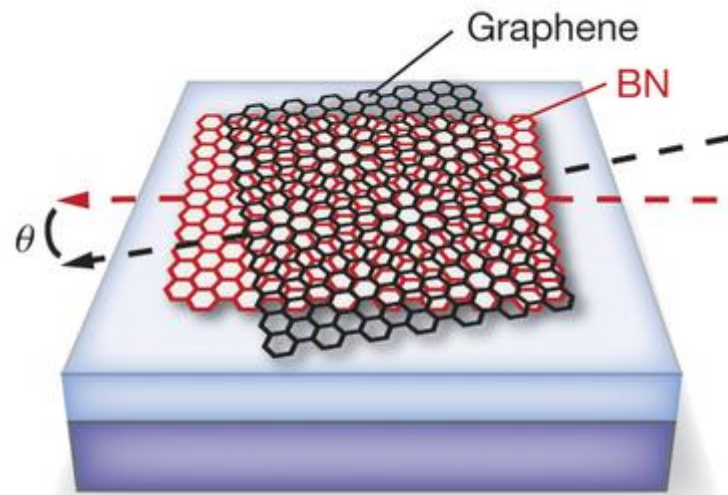


- Diffusive scattering due to roughness at device edges and gates boundaries
- Imperfect collimation of transport at first gate

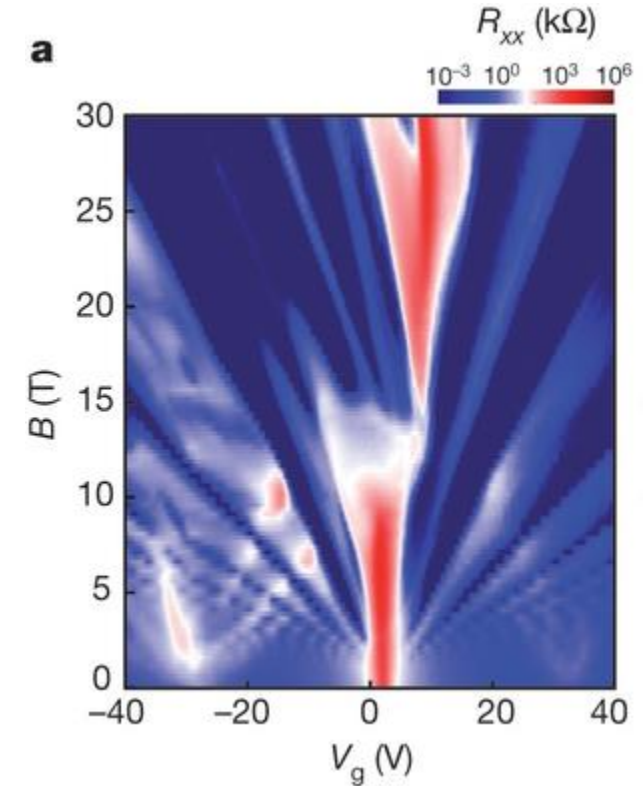
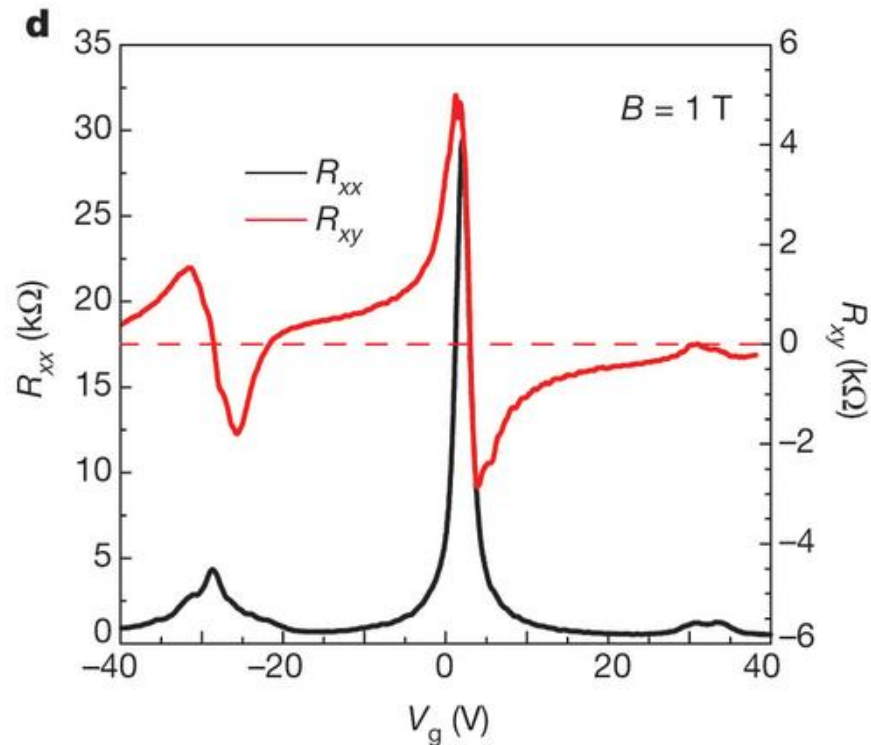
Deeper solution:
band structure engineering

Wilmart, et al. *2D Materials* 1.1 (2014)
Morikawa, et al. arXiv:1702.04039 (2017)

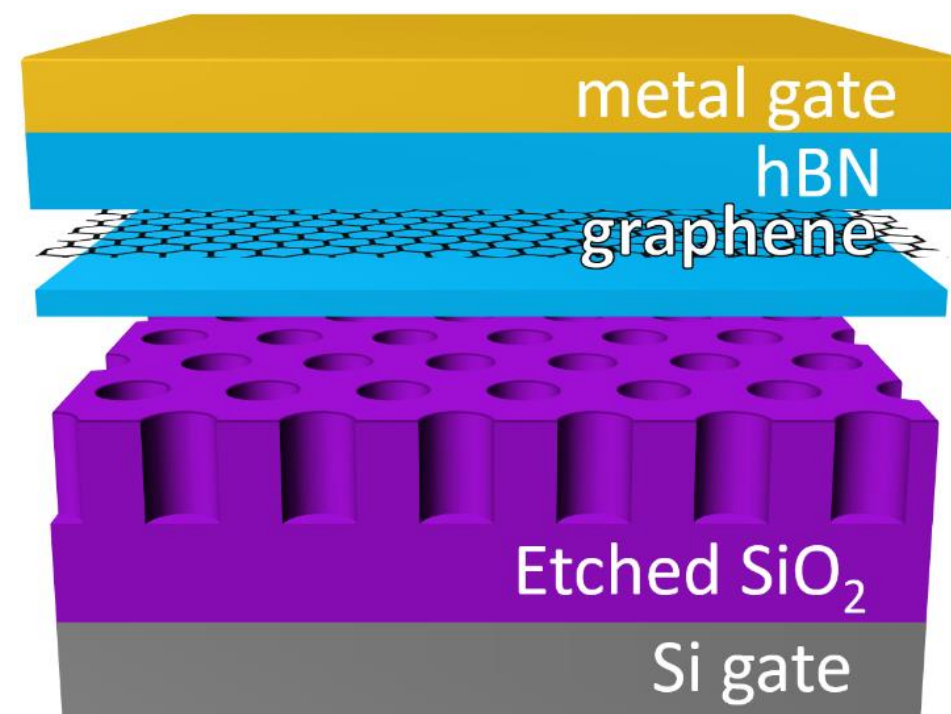
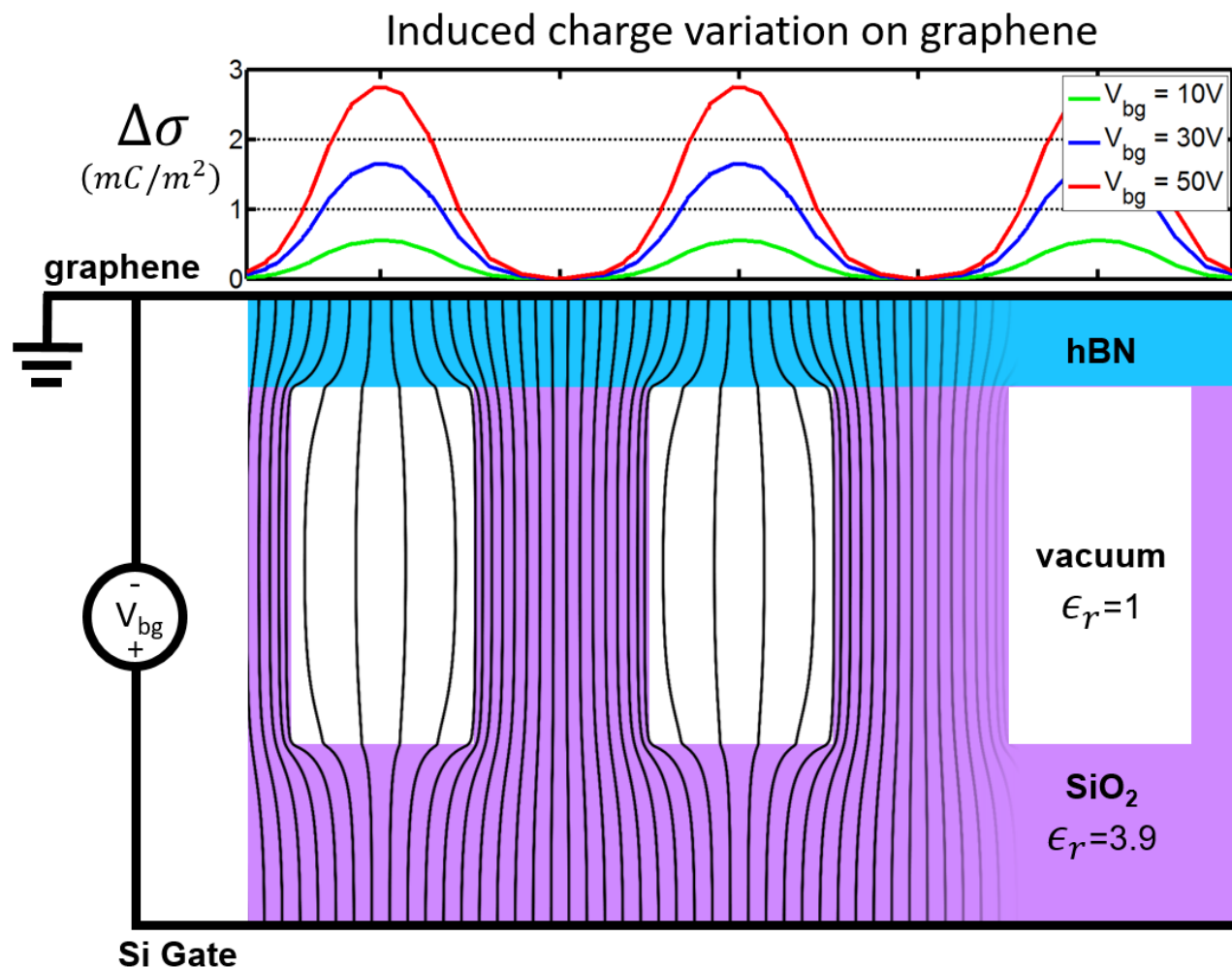
Graphene superlattices: Hofstadter



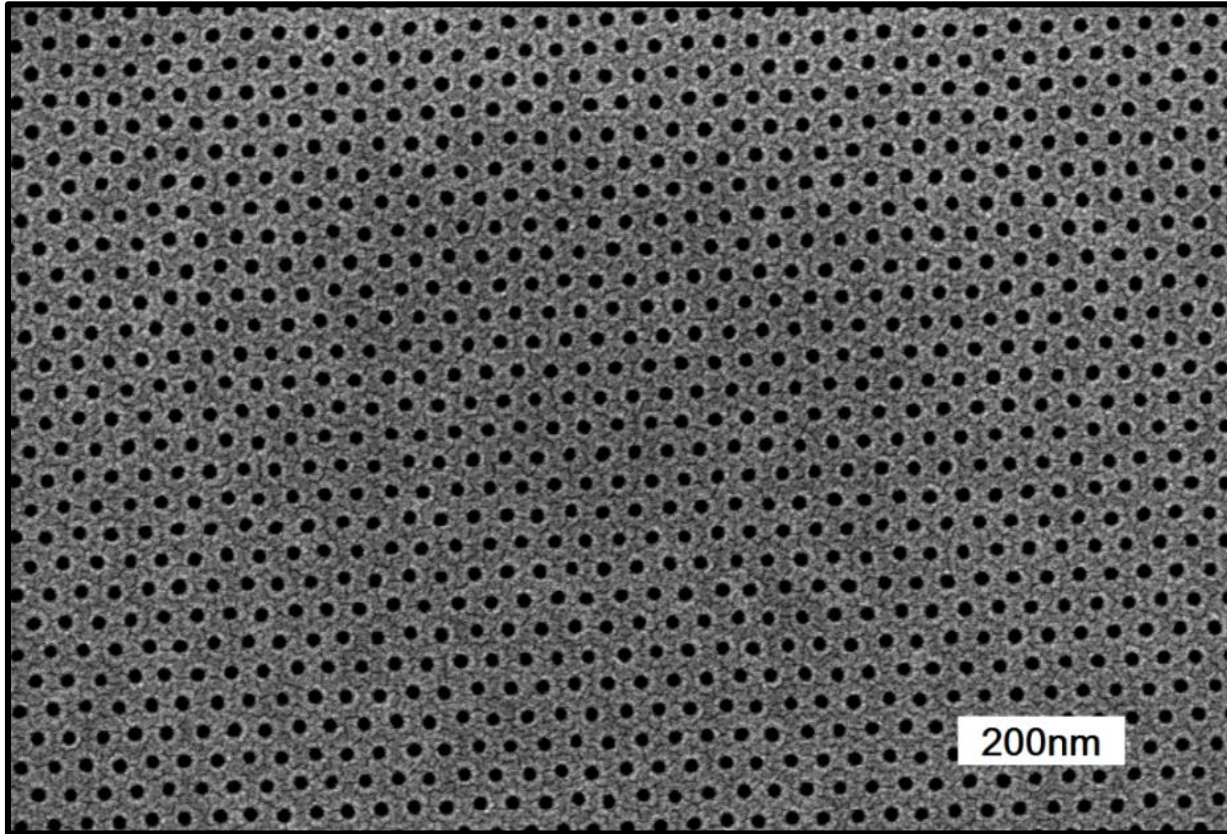
Hexagonal geometry
 $\lambda \geq 14\text{nm}$



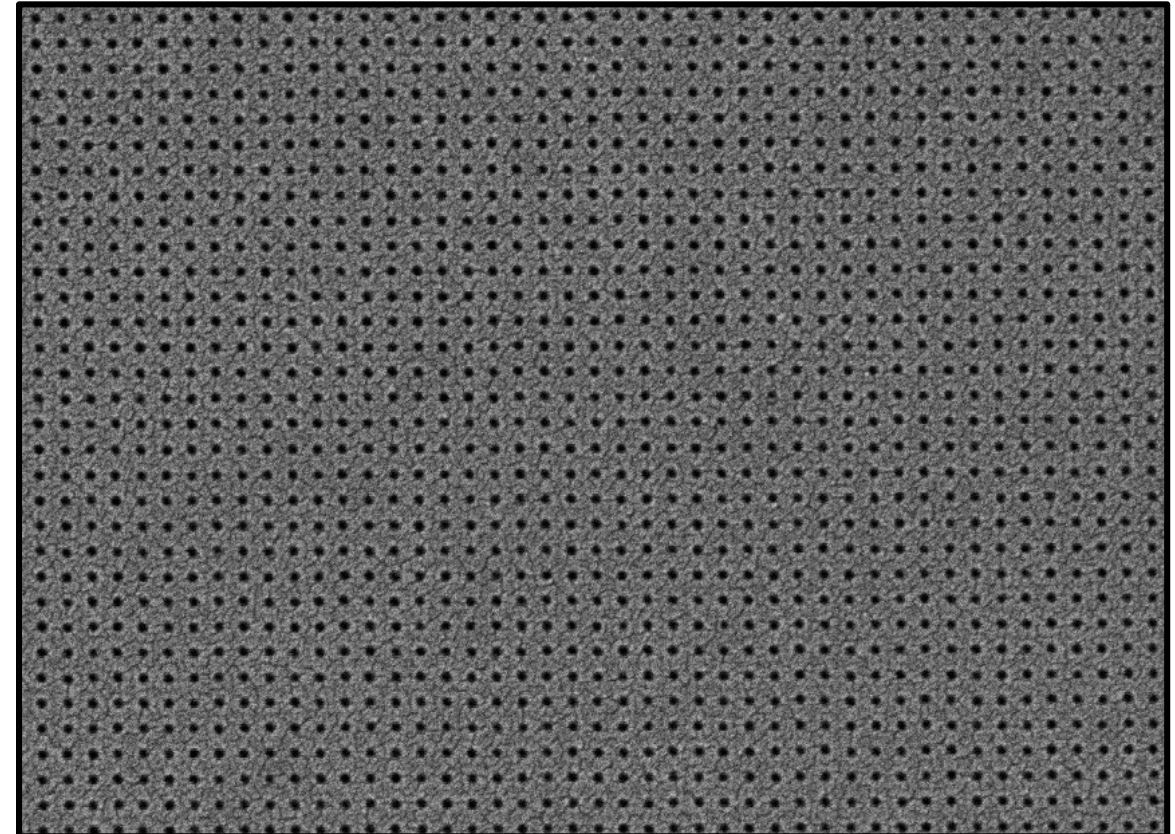
Dielectric-modulated electrostatic gating



SiO₂ patterning

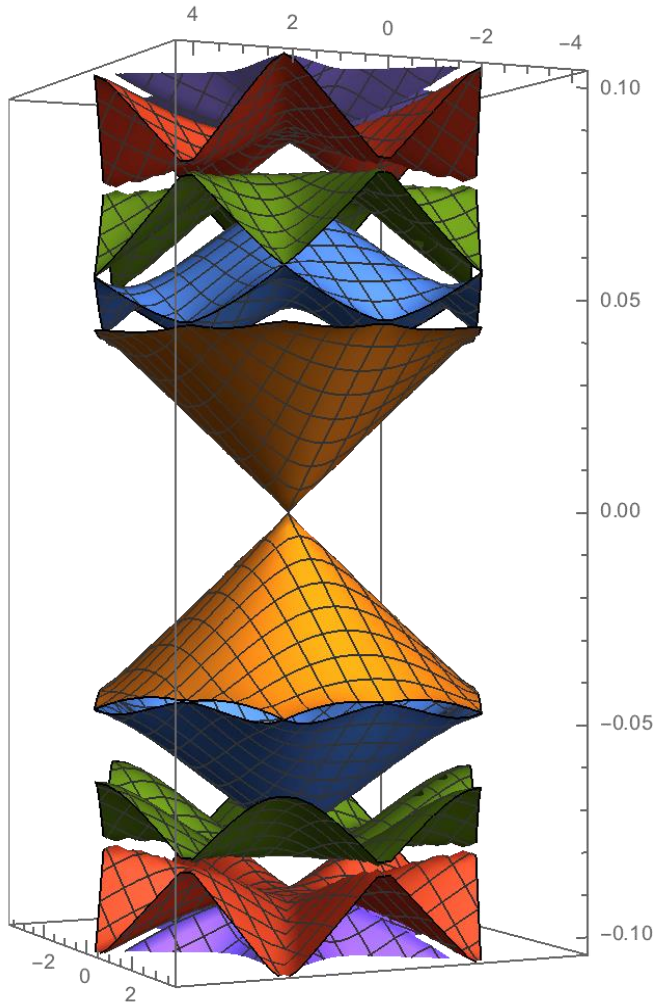


Triangular 40nm pitch



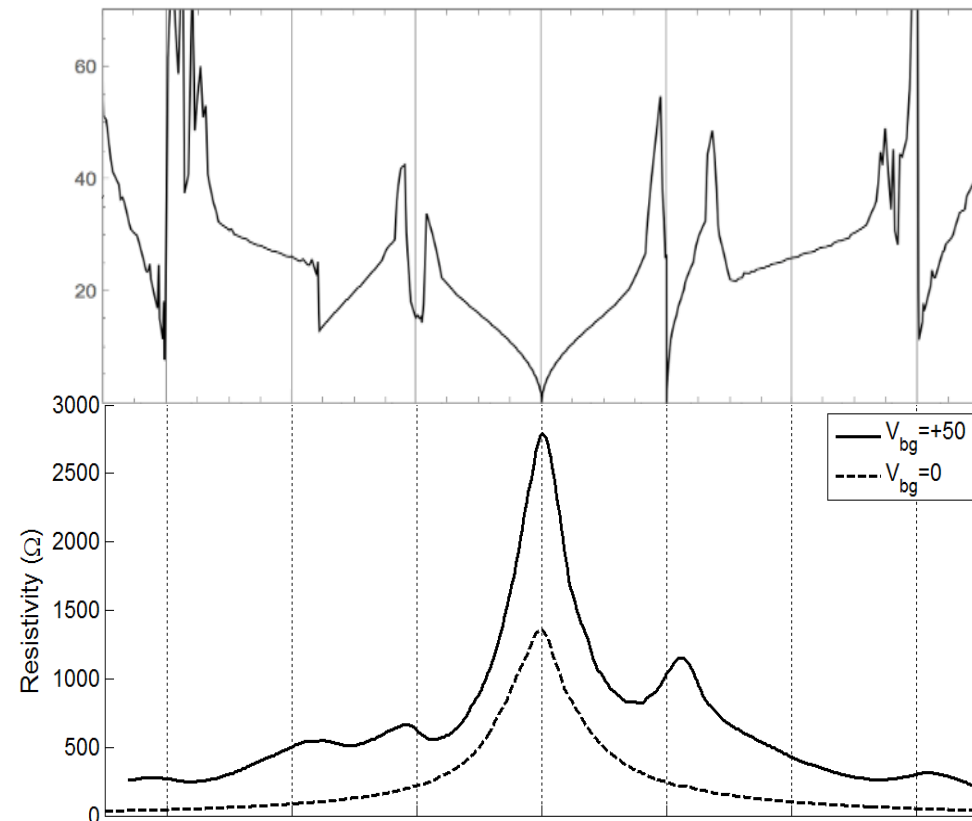
Square 35nm pitch

Triangular superlattice



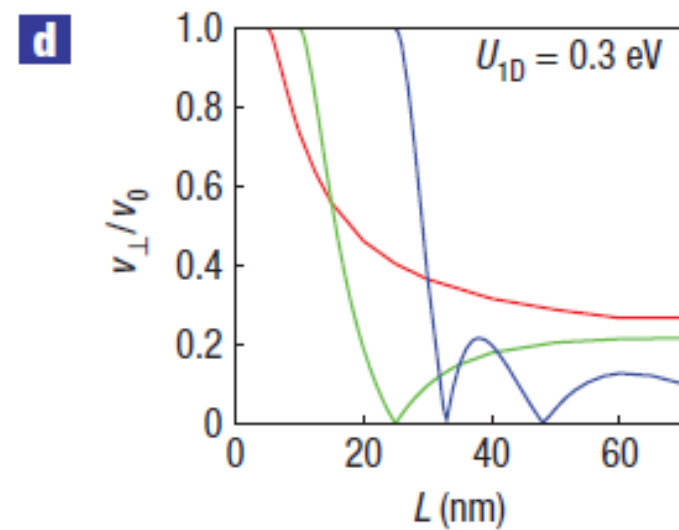
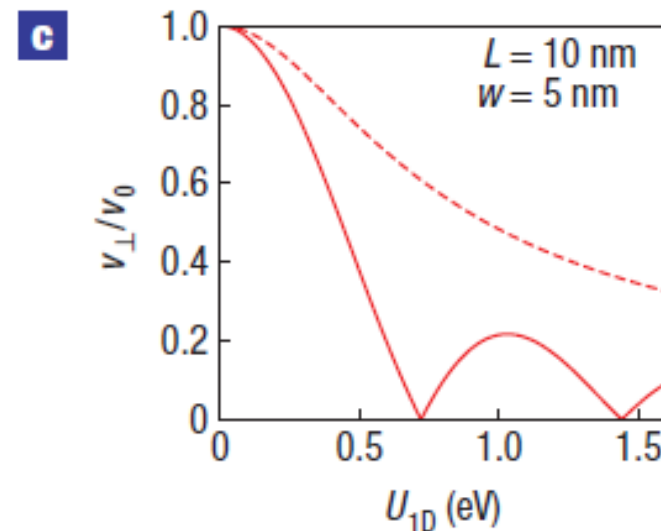
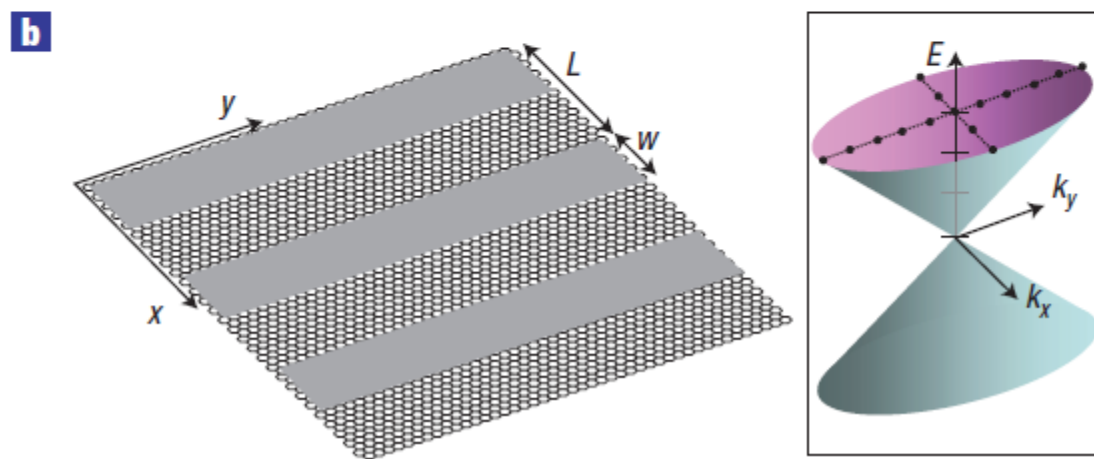
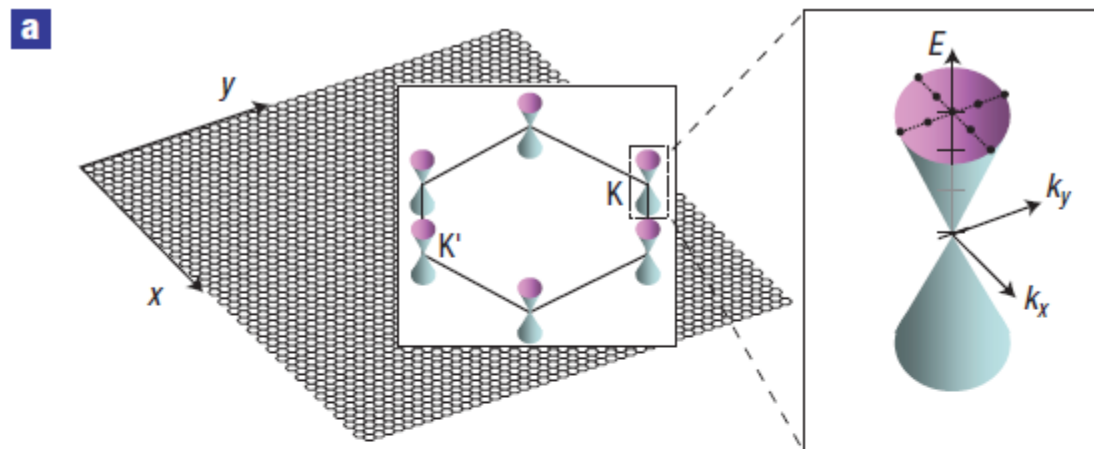
Mikito Koshino – Tohoku University

$$n_0 = \frac{1}{A} = \frac{2}{\sqrt{3}a^2} \quad a = 40\text{nm}, \text{triangular lattice}$$

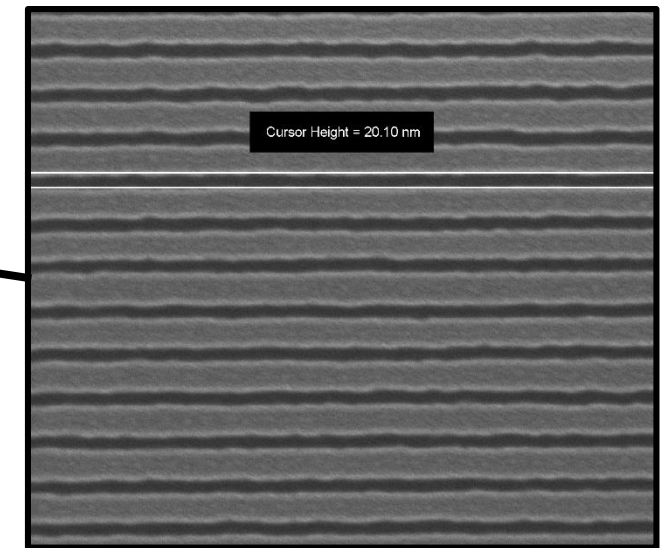
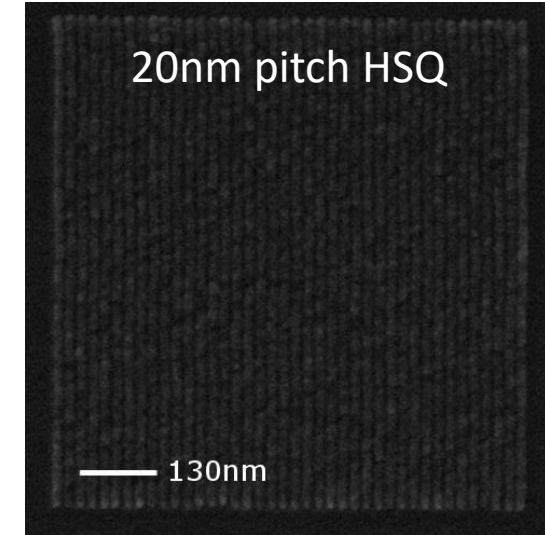
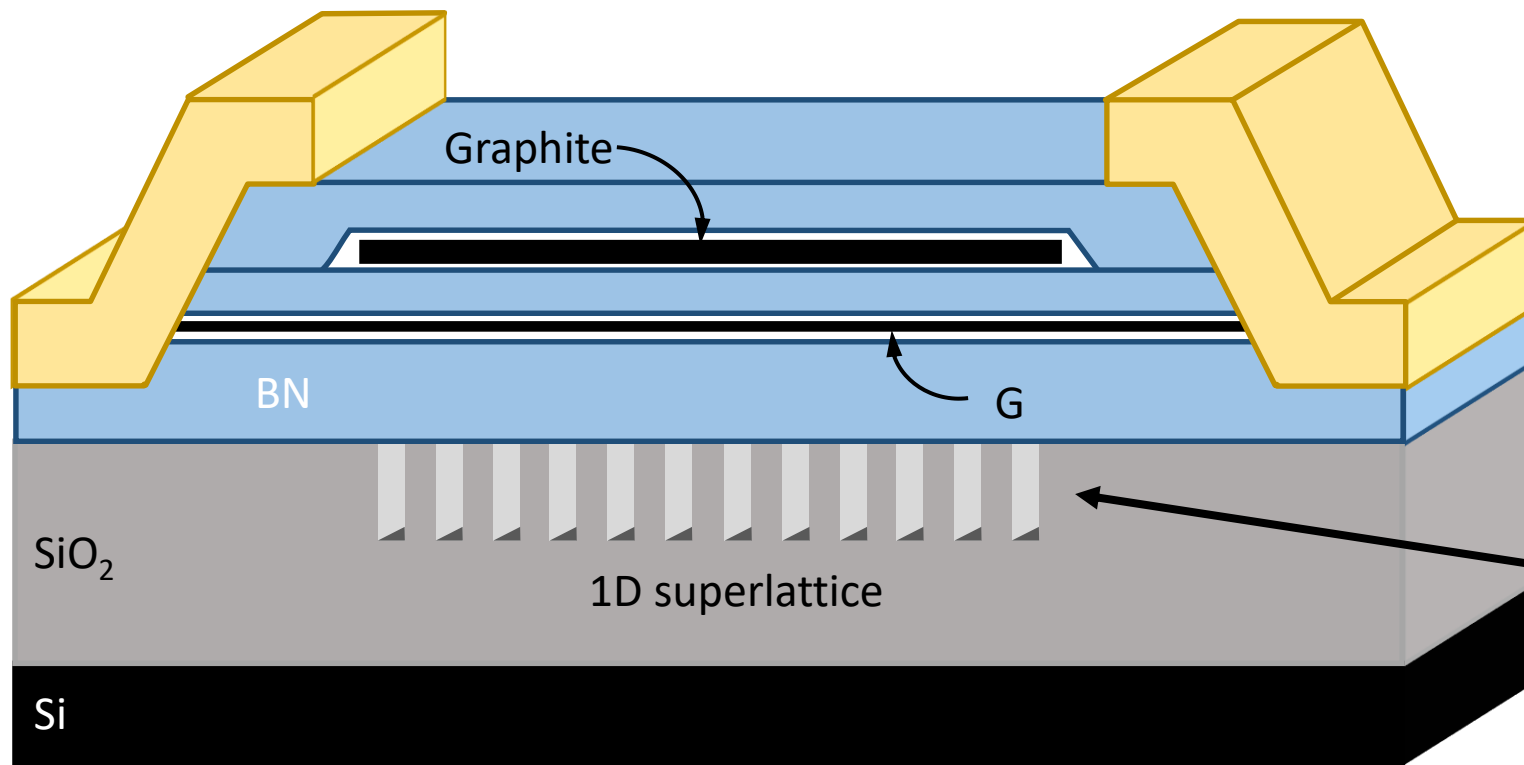

 C. Forsythe, et al. *unpublished*

- Highly customizable
- Switchable
- Interesting physics at easily-achieved B-field (3.5T rather than 35T)
- Significantly altered electronic properties

One-dimensional superlattices



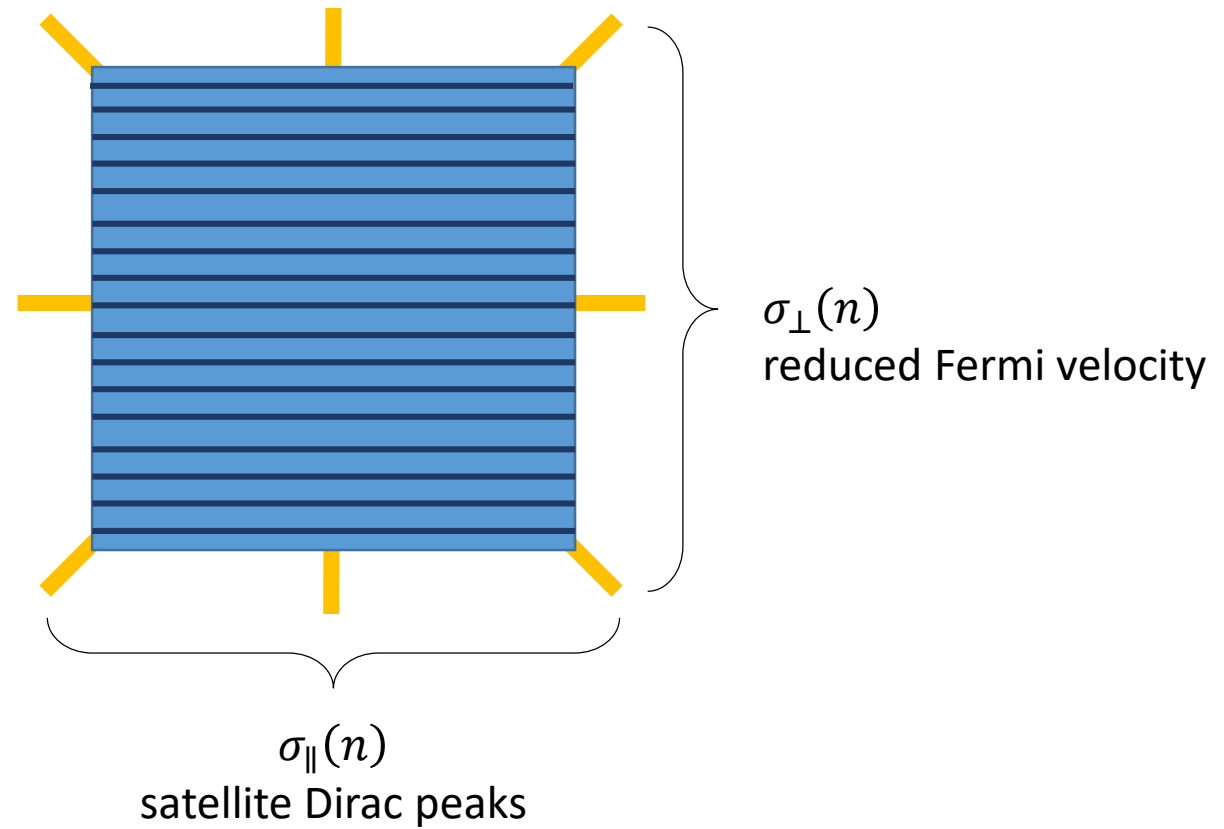
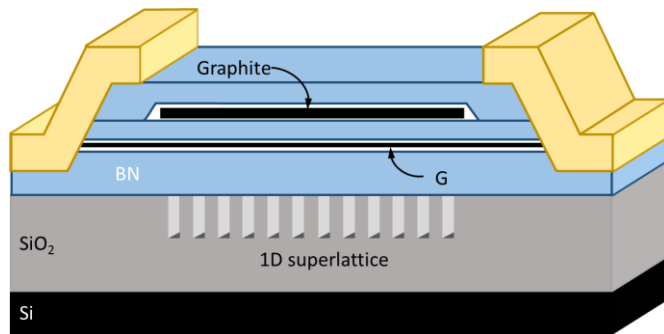
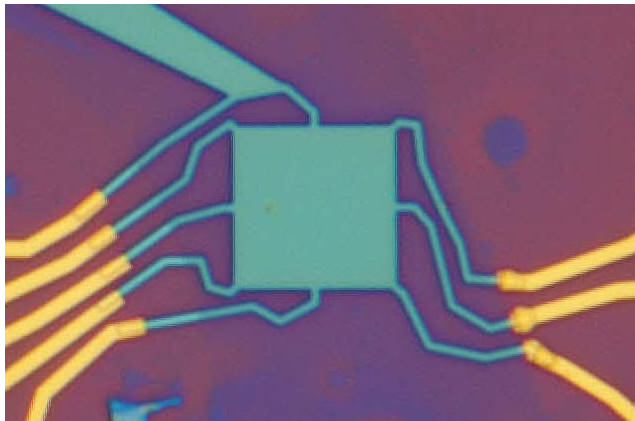
Initial device design



60nm pitch SiO₂ trenches

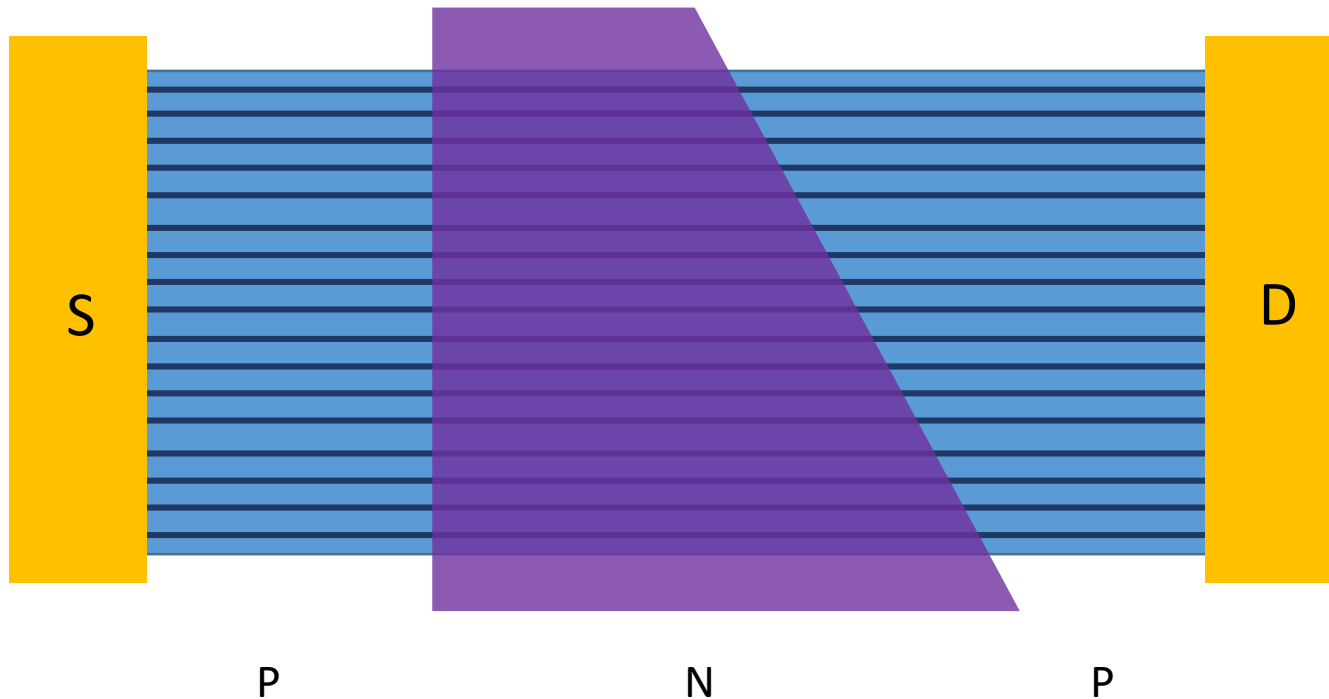
Measuring anisotropic transport

$$\sigma_{\perp} \neq \sigma_{\parallel}$$



Application to split-gate gFETs

Proposed device design



- Superlattice parameters tuned to suppress perpendicular conduction ($\sigma_{\perp} \sim v_{\perp} \rightarrow 0$)
- Right-angle junction to further collimate ballistic electrons
- Angled junction to switch on/off

Summary

- High-quality ballistic graphene junction
 - Negative refraction
 - Angular dependent transmission
- Band structure engineering
 - 2D superlattice gating achieved
 - 1D superlattices near
- Future of electron optics switch
 - Sharper junction
 - Angled-gate with anisotropic transport
 - Scaling for room temperature applications

Acknowledgements

We thank P. Kim, A. Pasupathy and J.-D. Pillet for helpful discussion, and R. Ribeiro for fabrication assistance.

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Thank you.